



CMOS Image Sensors at the Rutherford Appleton Laboratory and ... a bit more

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- Introduction. STFC and some of its detector activities
- CMOS image sensors for science
 - Large area CMOS image sensor
 - Achilles
 - Lassena
 - Percival
 - Ultra-high speed CMOS image sensors
 - PImMS
 - Kirana
 - Conclusion



Science and Technology Facilities Council

UK Astronomy Technology Centre
Edinburgh



Polaris House
Swindon, Wiltshire



Chilbolton Observatory
Stockbridge, Hampshire



Daresbury Laboratory
Daresbury Science and Innovation Campus
Warrington, Cheshire



Rutherford Appleton Laboratory
Harwell Oxford Science and Innovation Campus



Isaac Newton Group of Telescopes
La Palma



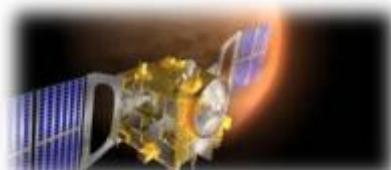
STFC manage the UK contribution to large scale facilities in the world



- CERN



- European Southern Observatory ESO



- European Space Agency ESA



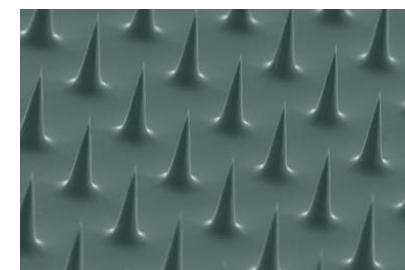
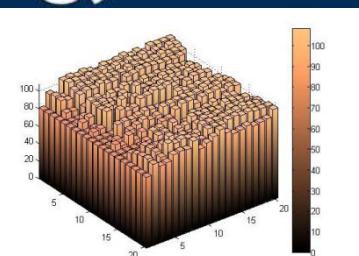
- European Synchrotron Radiation Facility ESRF



- Institute Laue-Langevin ILL

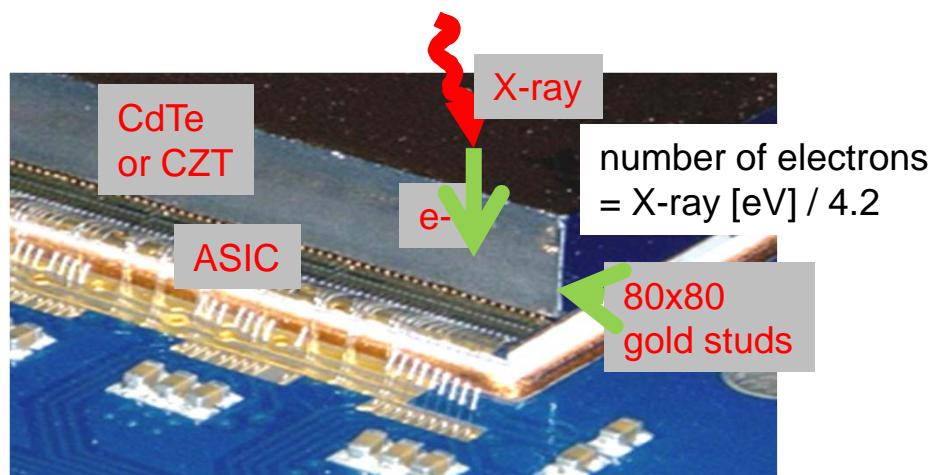


Technology



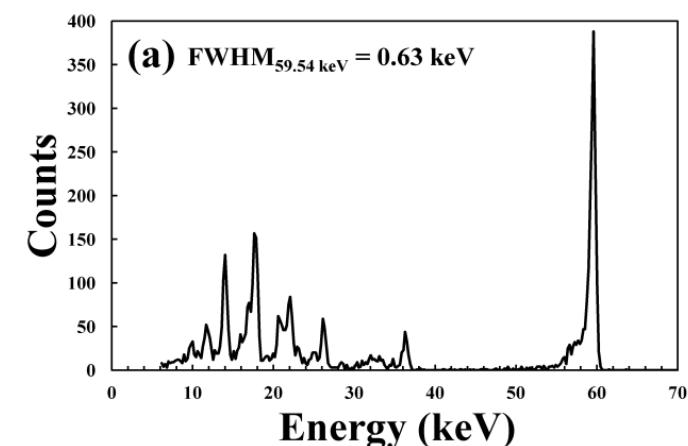
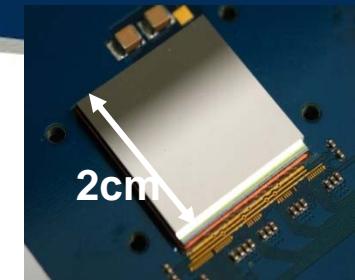


Energy resolving, pixel detector



Hexitec ASIC

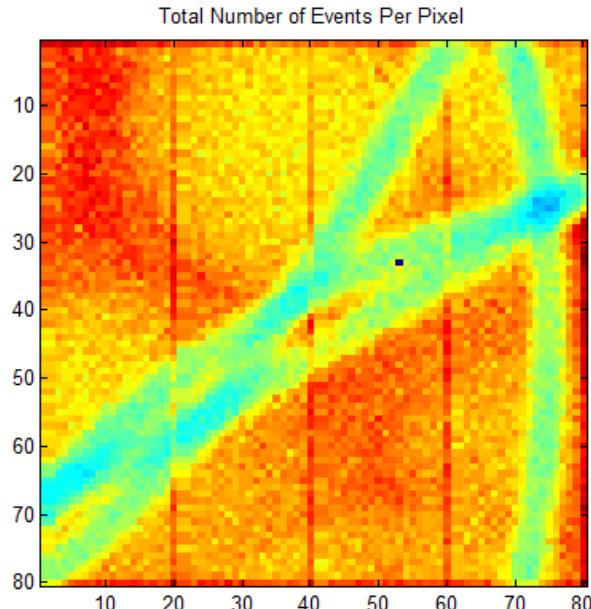
- 80x80 pixels
- Energy Range: 4-200 keV
- 1mm CdTe - 500V Bias
- $\text{FWHM}_{@60\text{keV}} = 0.8 \pm 0.2 \text{ keV}$
- (second range 12-600keV)



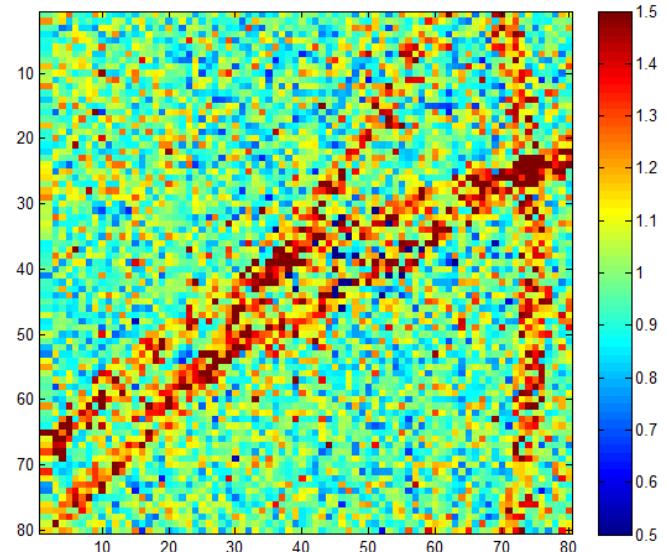
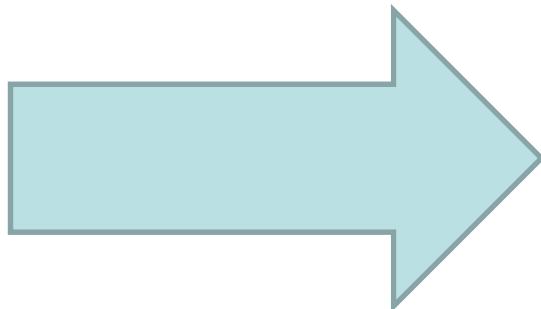
10,000 fps @ rolling shutter



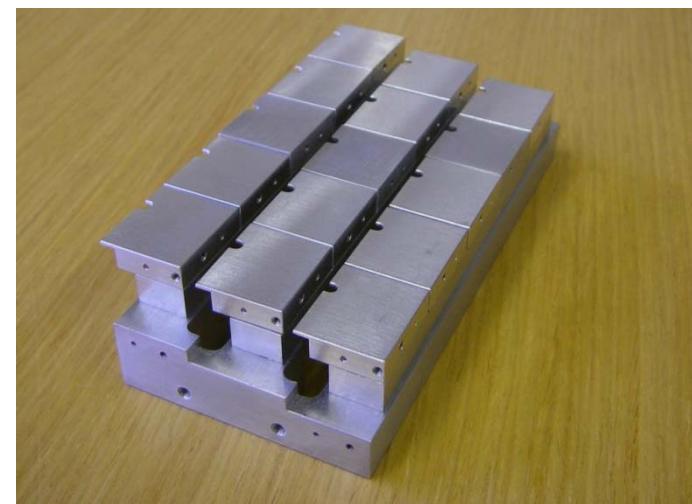
Hexitec: K-edge Transmission Imaging



Subtraction to remove background and leave I detail



Multi-module, large area sensor





Large Pixelated Detector

LPD is a high speed (4.5MHz) and high dynamic range (10^5 @ 12keV) integrating camera system.

Scalable system

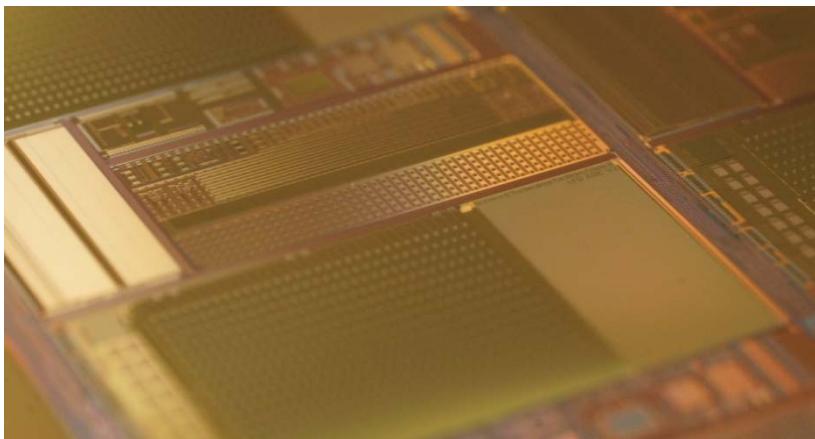


Optimum Energy Range	5 keV – 20 keV
Sensor Thickness	500 μ m
Pixel Size	500 x 500 μ m
Dynamic Range at 12 keV	10^5
Inactive area	13%
Max. Frame Rate	4.5 MHz
Min. Frame Rate	10 KHz
Gain Factors	1x, 10x, 100x
Storage Capacity	512 x 3
Data Output Rate (Mpix)	10GBs

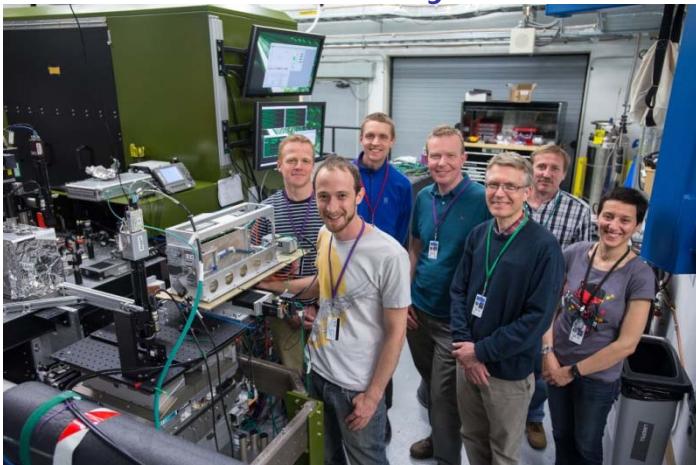




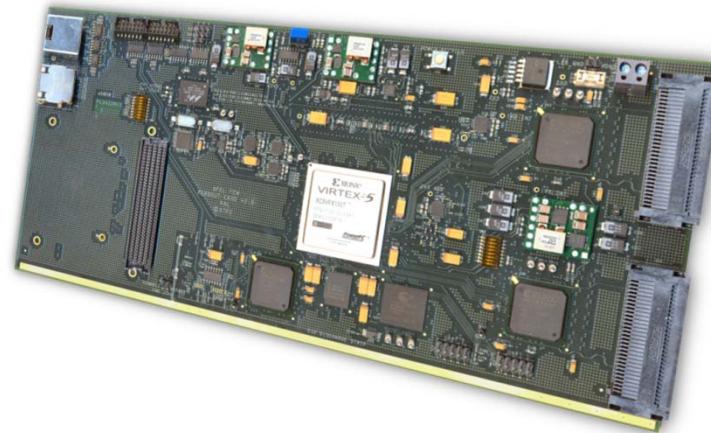
Custom ASIC in 130 nm CMOS



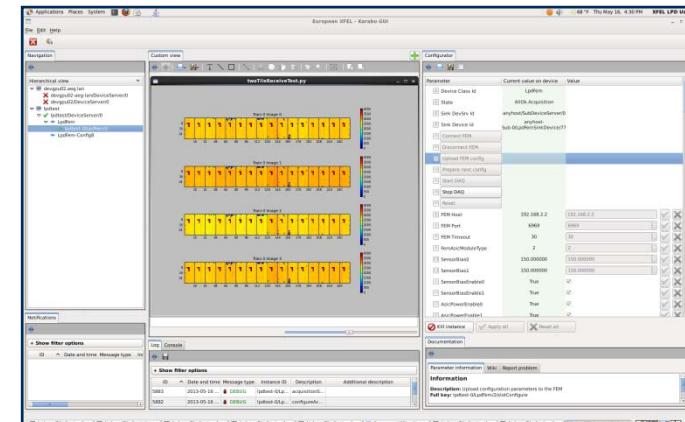
The LPD team during the beam test at LCLS this year



Custom DAQ. 10Gbit links

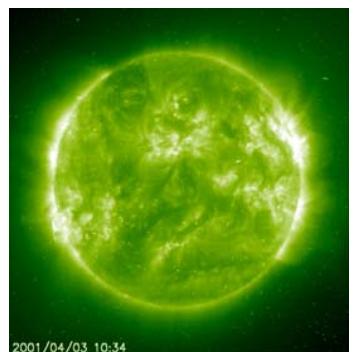
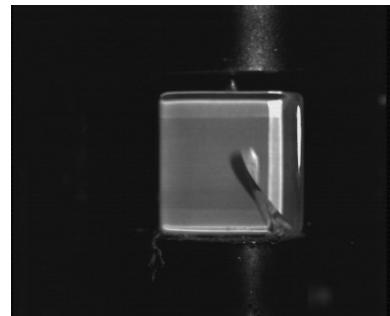
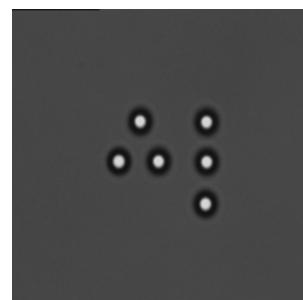
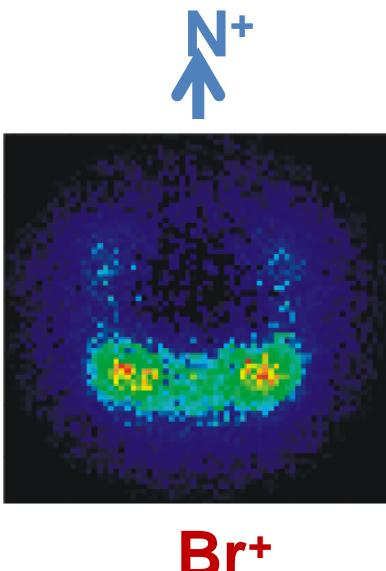
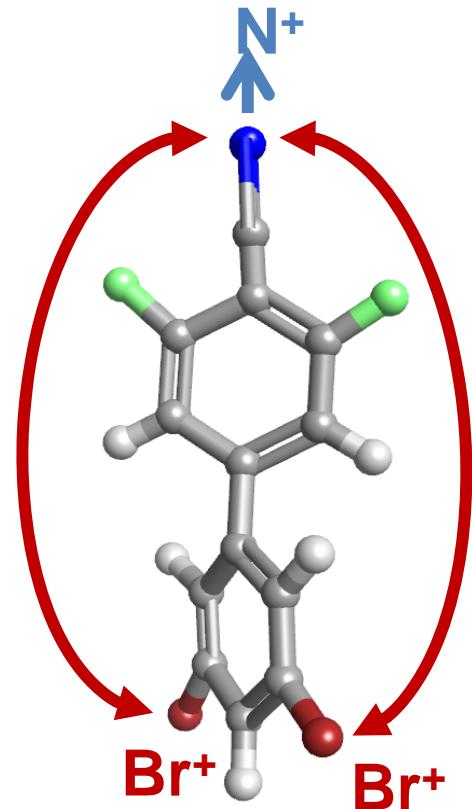
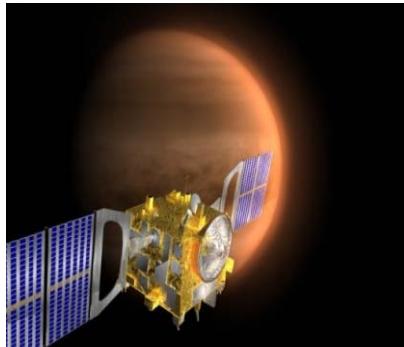


Custom S/W integrated with machine S/W



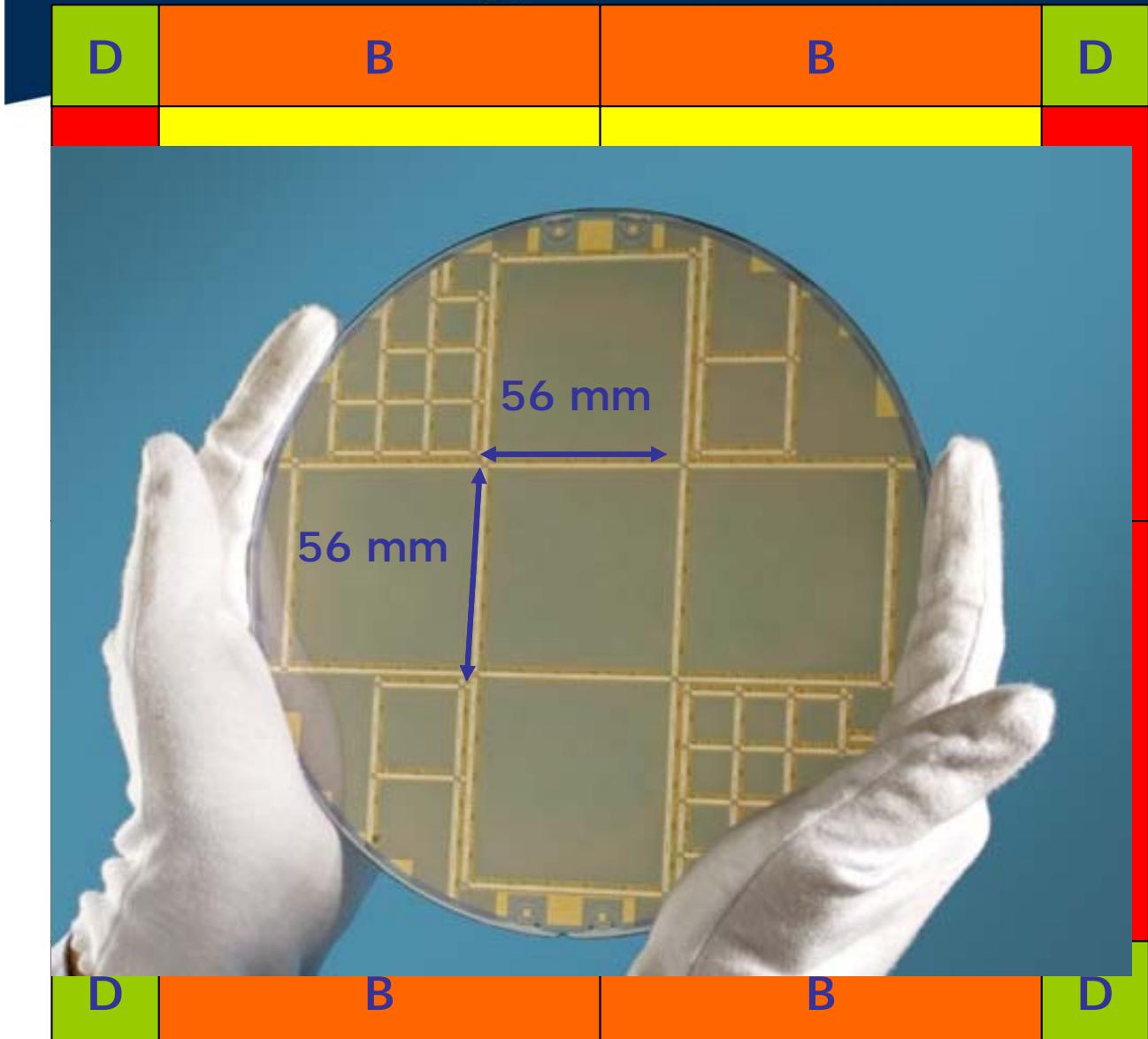


CMOS Image Sensor at RAL





Large area sensor. Stitching.



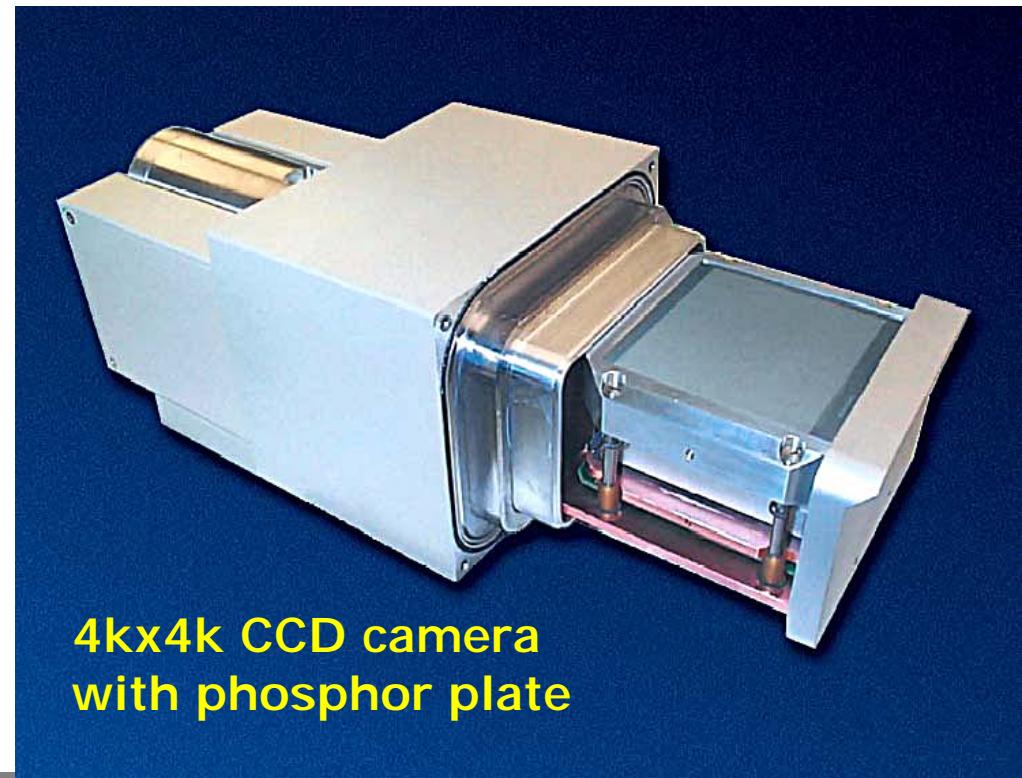
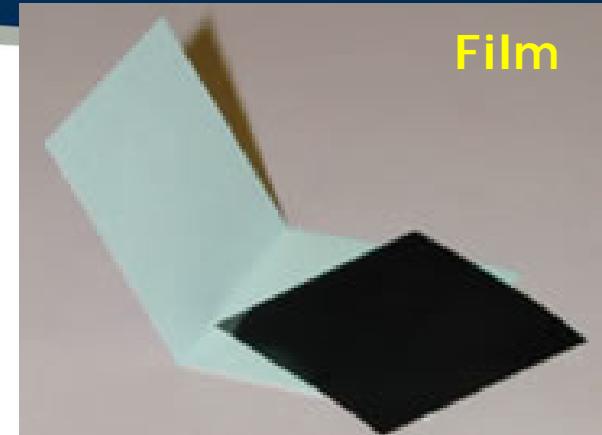
Sensor size freed from
reticle limitation → up
to single sensor per
wafer

Sensors of different
sizes can be
manufactured



Transmission Electron Microscopy (TEM). Prior art.

- Film: direct detection, very good resolution, non digital, poor S/N for weak exposure
- CCD with phosphor: indirect detection (radiation hardness), phosphor ruins spatial resolution, good for tomography



4kx4k CCD camera
with phosphor plate

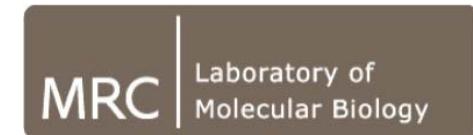
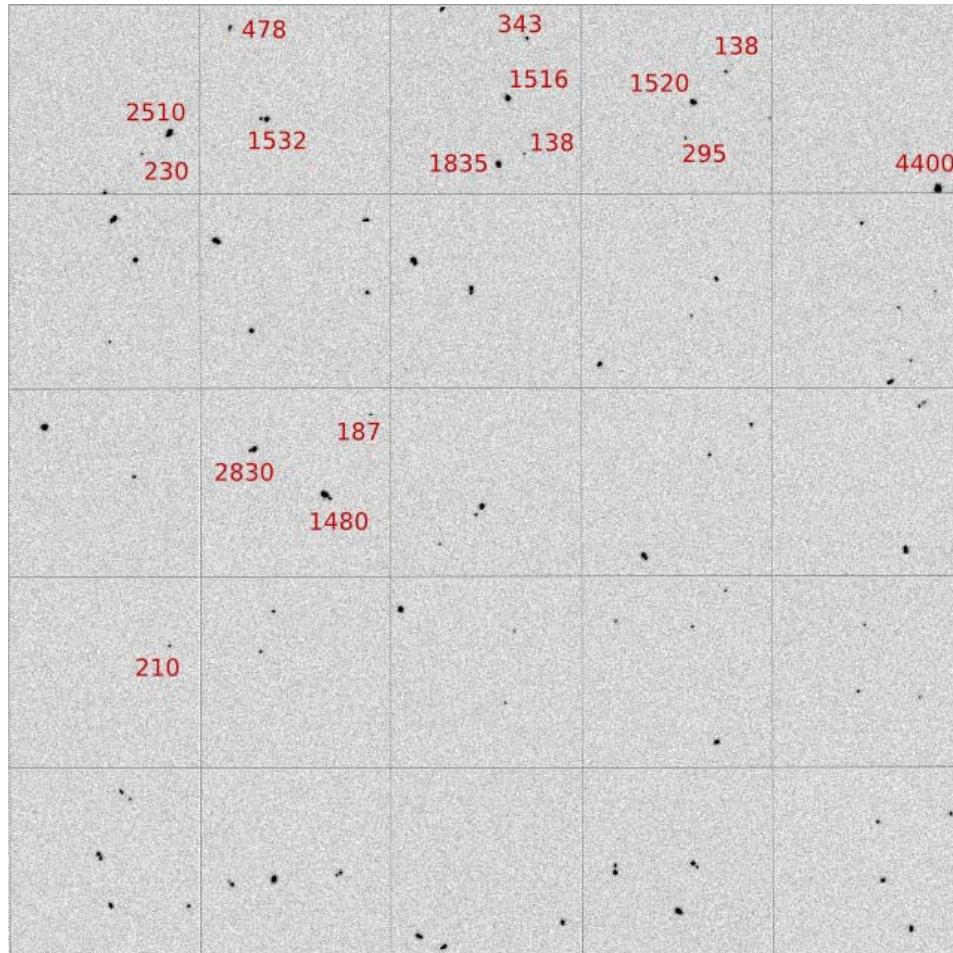


CMOS Sensor for TEM

- Direct detection
- Good single electron sensitivity
- Good MTF and DQE
- Radiation resistant
- 4Kx4K array
- 16 million pixels



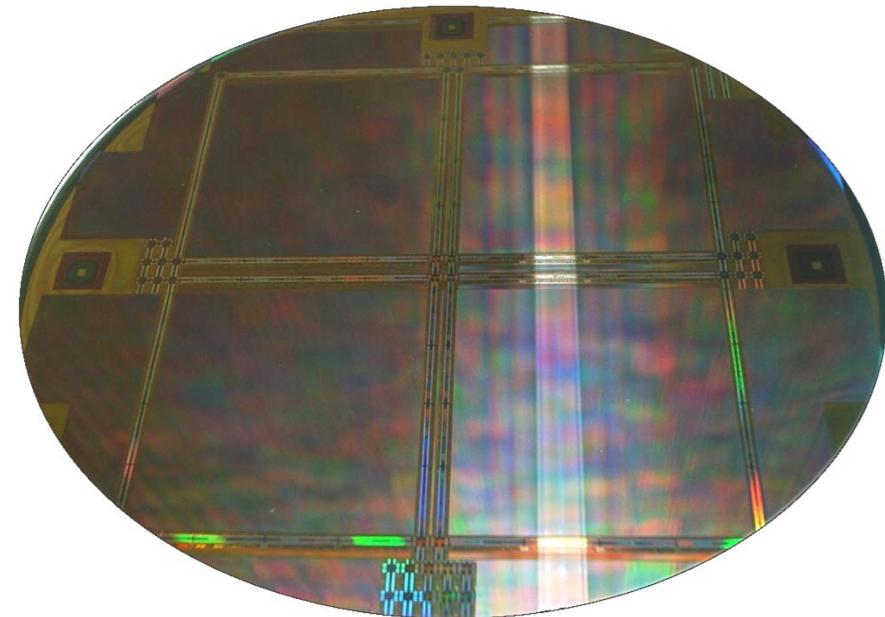
Detection of electrons in CMOS





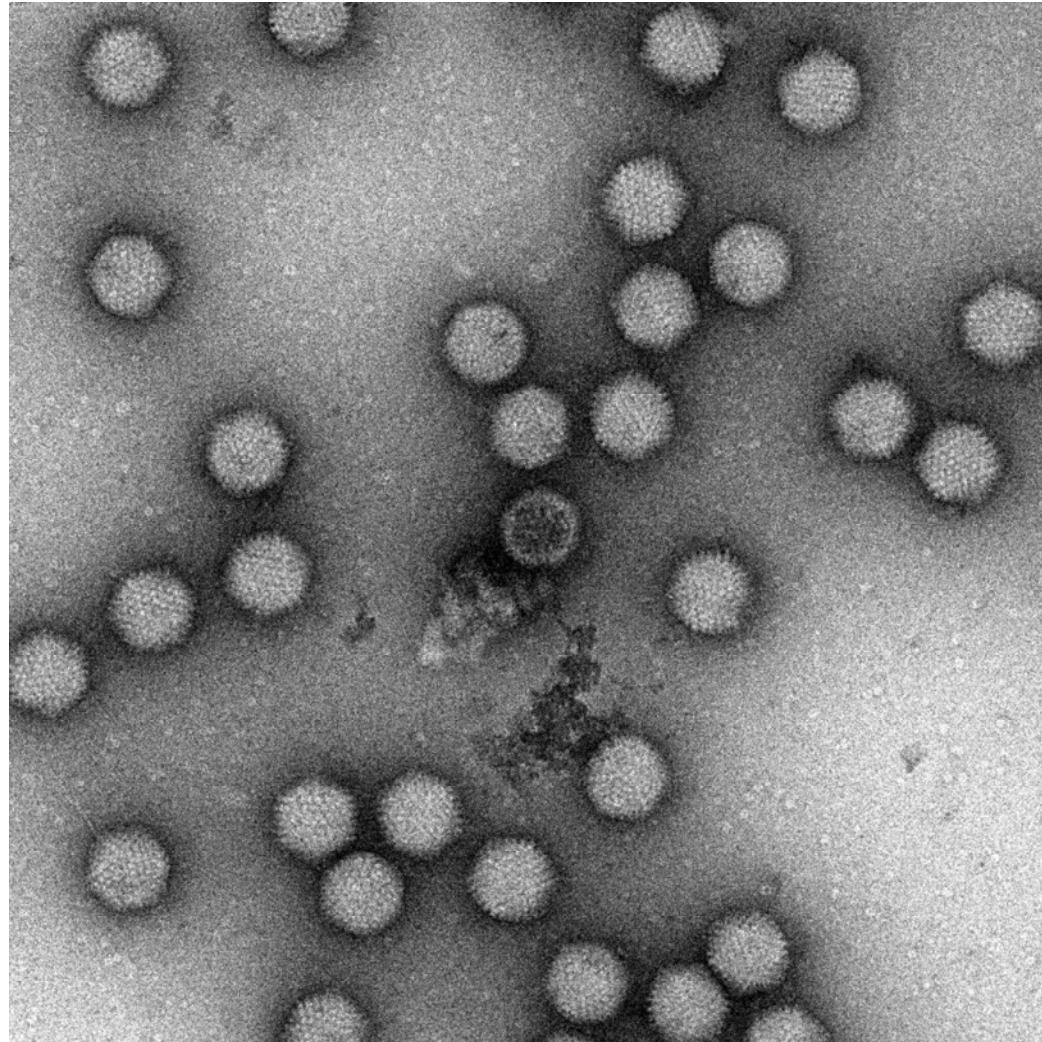
A 16Mpixel sensor for TEM

- 61x63 mm² silicon area (4 dies per wafer)
- 0.35µm CMOS
- 16 million pixels, 4Kx4K array
- 14 µm pixels
- 32 analogue outputs
- 40 fps
- Pixel binning 1X, 2X and 4X
- ROI readout
- 83 e- rms noise
- Full well 120ke-
- Radiation hardness of >500 million of primary electrons/pixel (>20 Mrad)
- 20% QE for visible light





Adenovirus

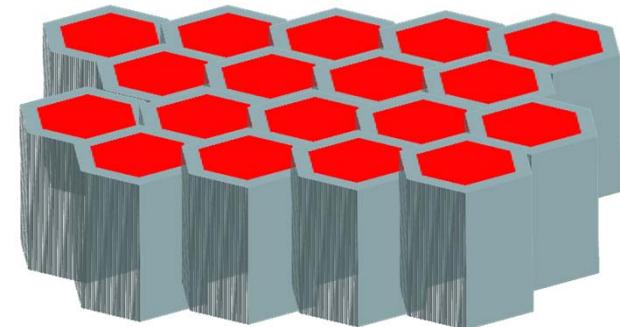


Courtesy of G. McMullan (LMB, Cambridge, UK)



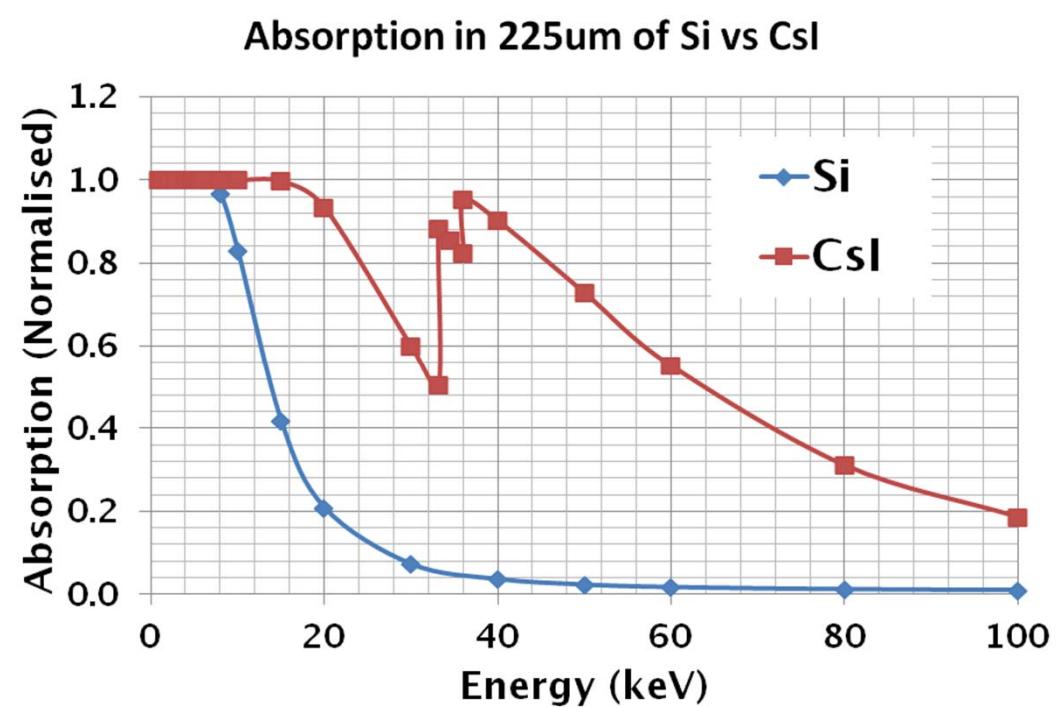
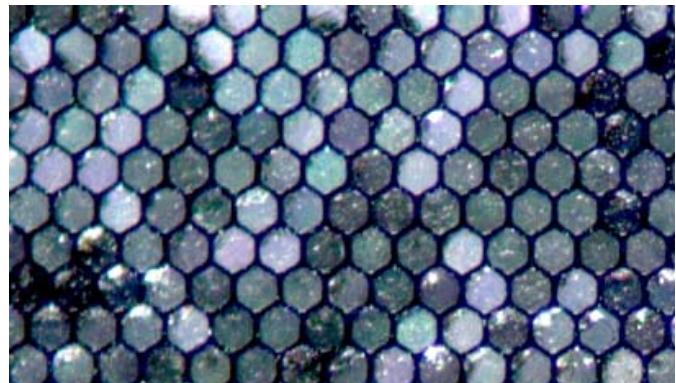
Structured scintillators

Mesh in a silicon wafer
filled with CsI



'Artist view'

Photograph





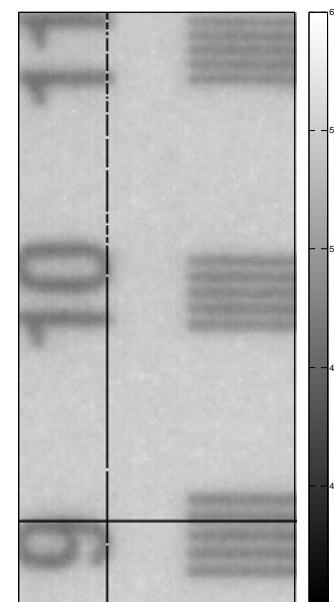
Contrast

Scintillator	CTF at 10LP/mm
Standard A	18%
New Bv1 25um pore	$70 \pm 10\%$
New Bv2 30.8um pore	$55 \pm 5\%$

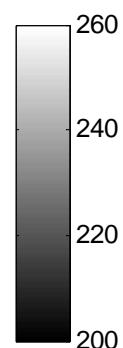
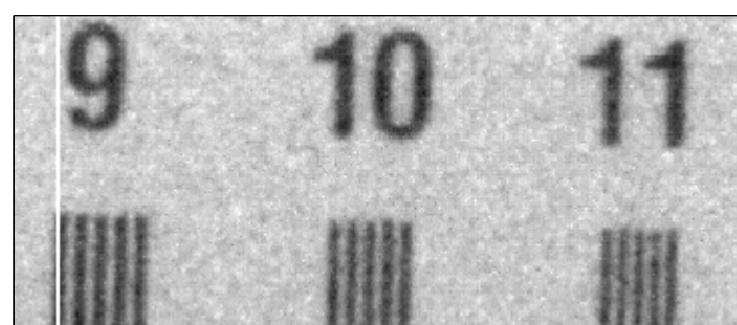
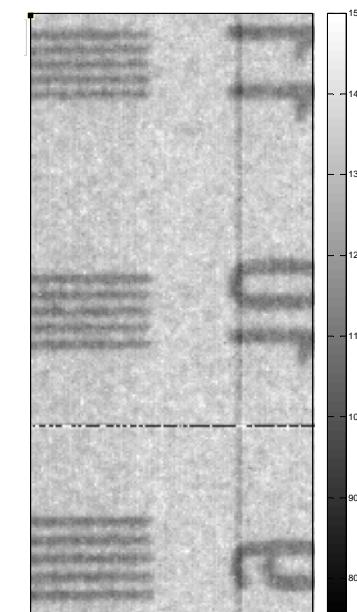
17 lpm @ 10%

All at 120kV and 3W – noise
gives uncertainty to CTF
(Contrast Transfer Function)
values.

Scint A



Scint B





Wafer-scale sensor for X-ray medical imaging

Motivations

- Extra-oral dental
- with tiling:
 - Mammography
 - Chest imaging
 - Security

...

Guidelines

- Wafer-scale sensor
- One sensor per 200 mm wafer
- 3-side buttable → 2xN tiling
- Radiation hard design
- Design for yield



Main features

- High resolution. 50 µm pixel.
- High-speed. Over 30 frames per second at full resolution.
- Low noise. 68 e- rms in full frame to give very high sensitivity.
- 139mmx120mm and 3-side buttable for large area coverage.
- High dynamic range. Multiple programmable integration times
- Binning x2, x4 and Region-Of-Interest (ROI) readout
- Manufactured in 180 nm CMOS Image Sensor process from TowerJazz Semiconductor



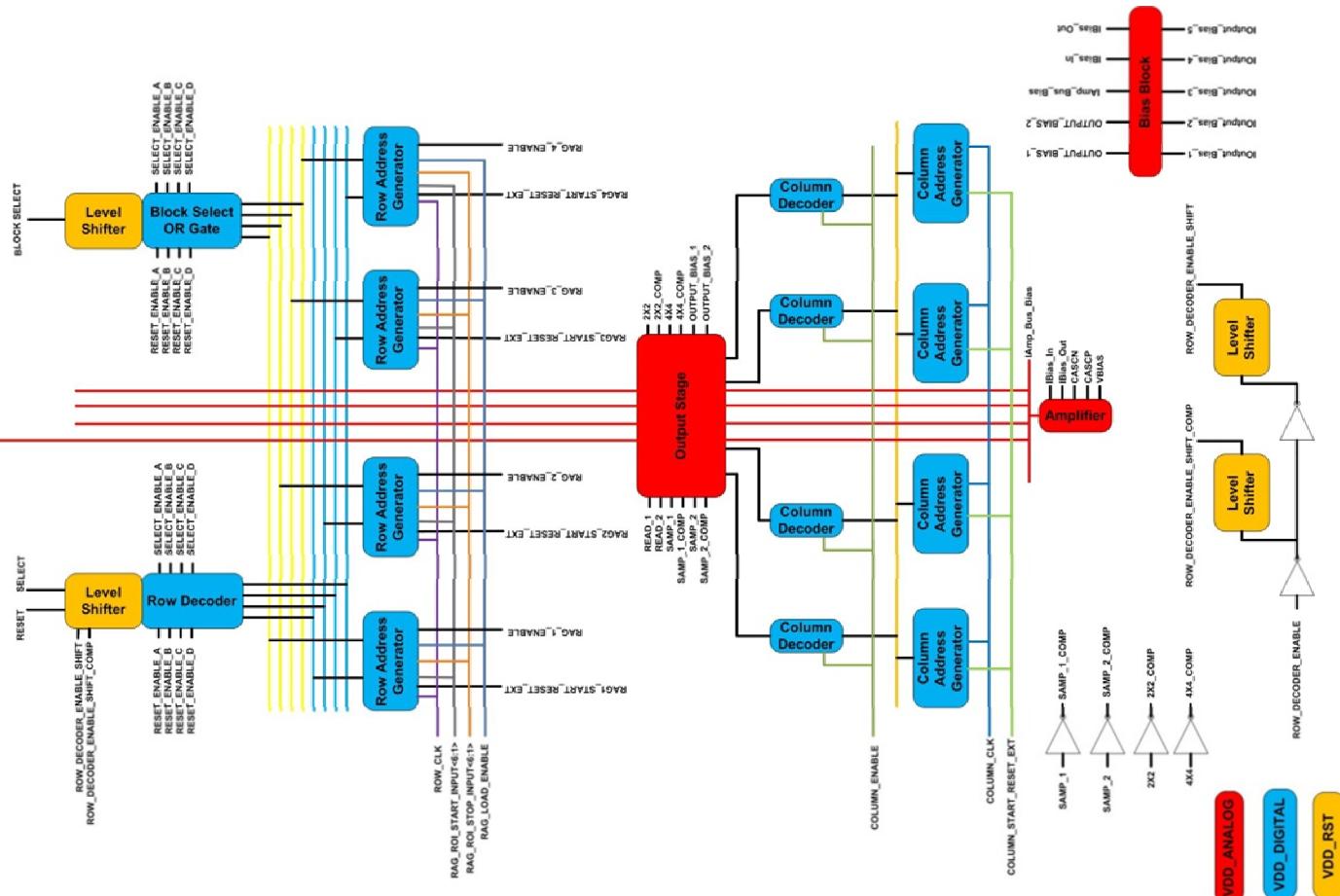
Lassena. Floorplan

To the pixel:

3T pixel base
with

Low noise,
large partially
pinned diode

Binning
capability





Lassena. A 6.7Mpixel, wafer-scale sensor

Optical performance			
Rms electronic noise	e-rms	68	Full resolution mode (i.e. no binning)
		335	Bin 2x2 mode
		608	Bin 4x4 mode
Linear full well	e-	112,000	Full resolution mode (i.e. no binning)
		1,253,000	Bin 2x2 mode
		5,012,000	Bin 4x4 mode
Maximum full well	e-	144,000	Full resolution mode (i.e. no binning)
		1,374,000	Bin 2x2 mode
		5,496,000	Bin 4x4 mode
Dynamic range (Linear)	bits	10.7	Full resolution mode (i.e. no binning)
		11.9	Bin 2x2 mode
		13.0	Bin 4x4 mode
Dynamic range (Maximum)	bits	11.0	Full resolution mode (i.e. no binning)
		12.0	Bin 2x2 mode
		13.1	Bin 4x4 mode
Readout speed	frames per second	35	Full resolution mode (i.e. no binning)
		70	Bin 2x2 mode
		140	Bin 4x4 mode
Quantum efficiency	Measured @ 540nm	50%	
Lag		Negligible	
Other			
Power supply	V	3.3	
Number of pads	480	All on one side	
Power Consumption (mW)	W	<2.5	CMOS only



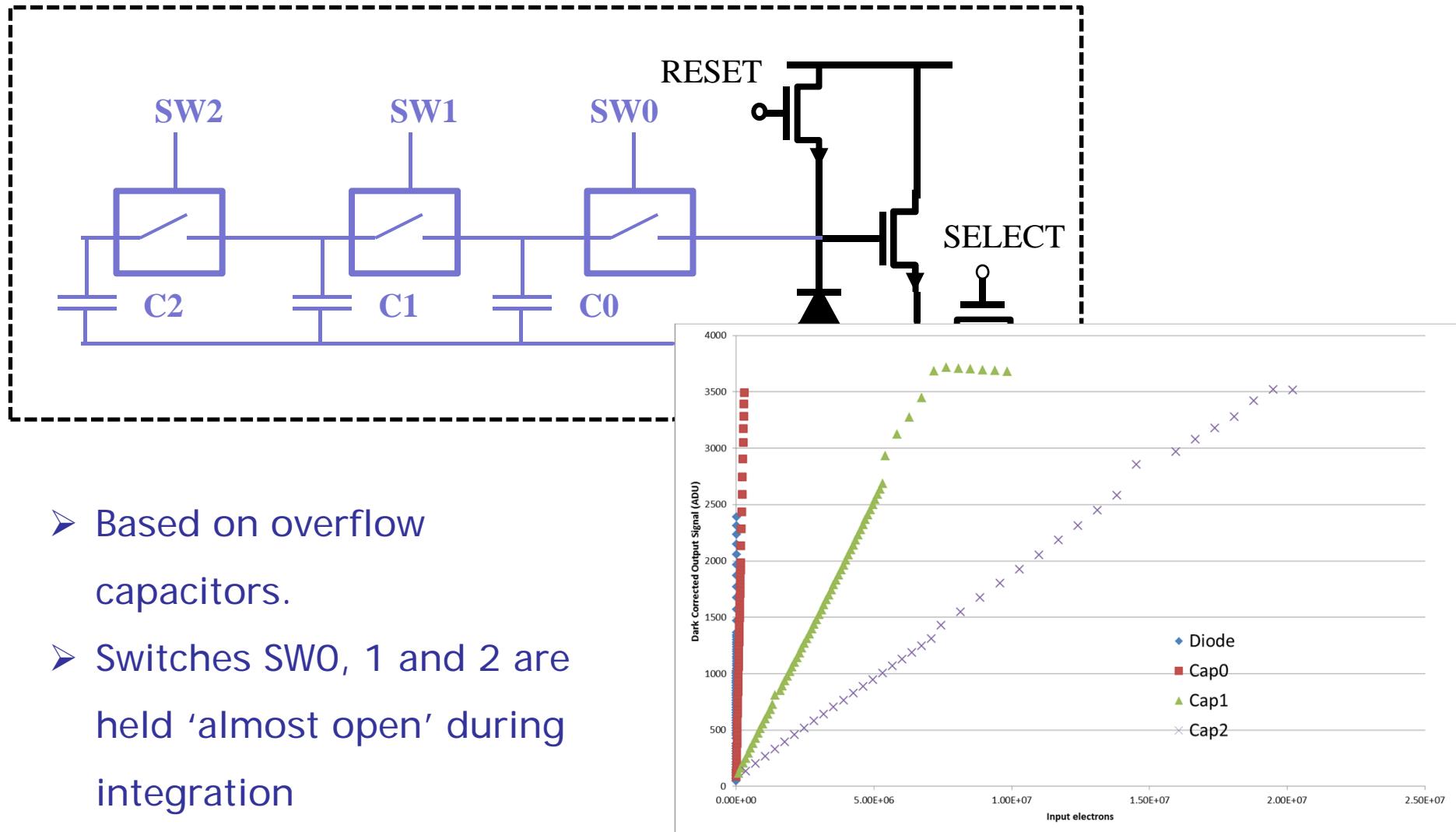
Pixelated Energy Resolving CMOS Imager, Versatile and Large





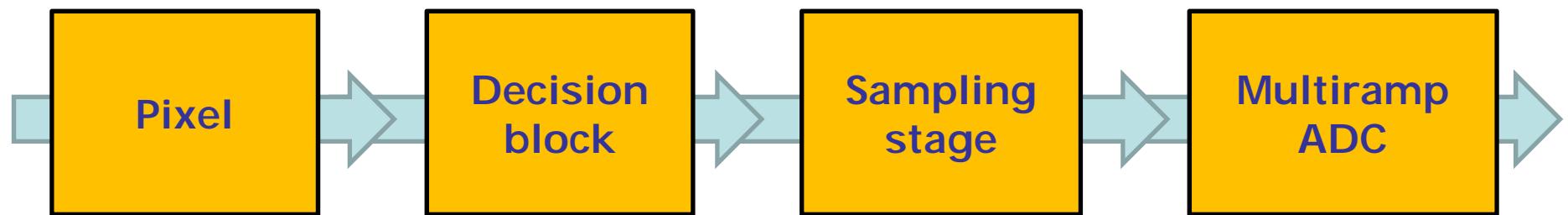
Percival target specifications

- Low energy X-ray detection $<\sim 2,000$ eV
- High efficiency → back-side illuminated and direct detection
- High resolution → 4kx4k on a 25 μ m pitch
- Good single photon sensitivity → low noise
- High dynamic range, i.e. up to $\sim 2 \times 10^5$ photons @ 250 eV → high dynamic range (HDR) pixel --> ~120dB or full well >10 Me-
- High frame rate → 120 fps
- Fully digital





Signal path



The diode is read first, then the three capacitors

It selects the lowest non saturated value

This value is sampled, as well as the reset value

Both sampled value and reset are converted

ADC conversion over 12 bits. 5 coarse plus 7 fine (plus 1 for over-range)
2 bits for gain, as selected by the decision block



Percival sensor floorplan

Preliminary specifications

- 16 MPix resolution
- 120 fps (digital CDS)
- High dynamic range (4 gains per pixel)
- 12+1bit ADC
- 15 bits per pixel (2 gain bits + 13 bits)
- Digital I/O (LVDS)
- 60 Gbit/sec continuous data rate



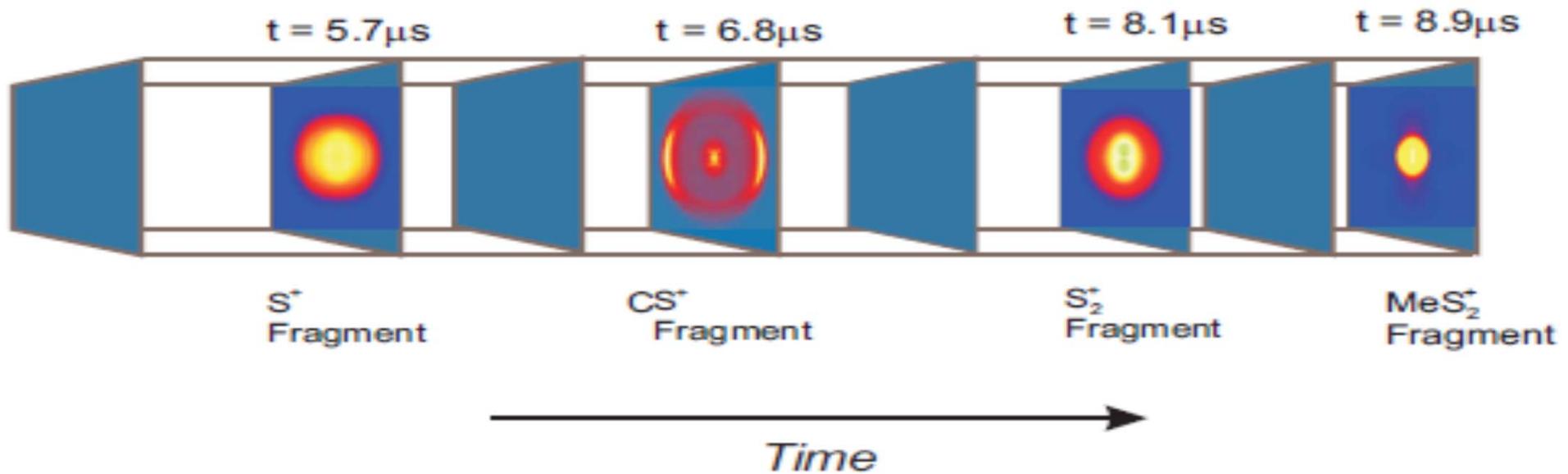


Time-Of-Flight Mass Spectroscopy



Requirements

- Spatial information
- Timing information

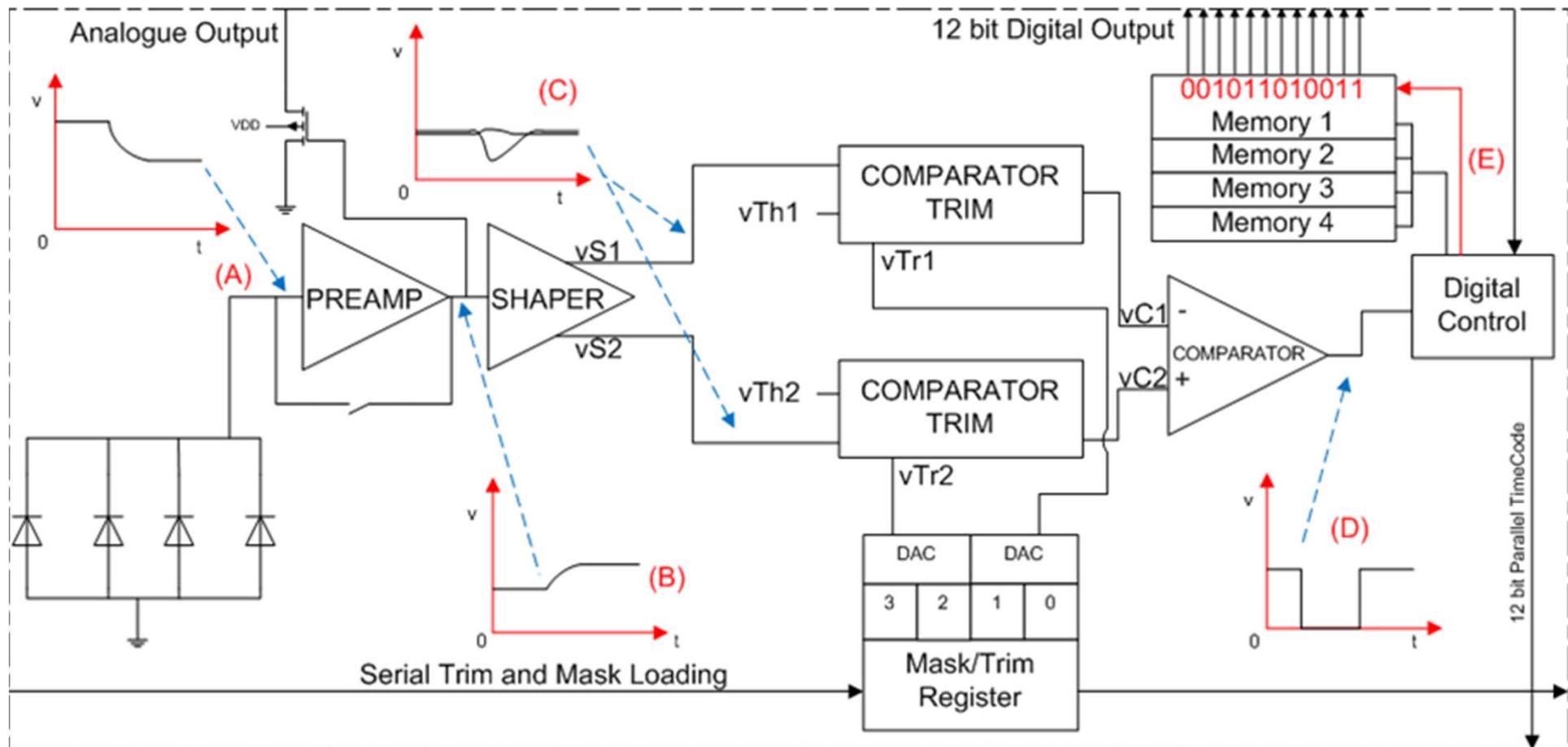


Courtesy of M. Brouard, C. Vaillance, R. Nickerson et al., Oxford University



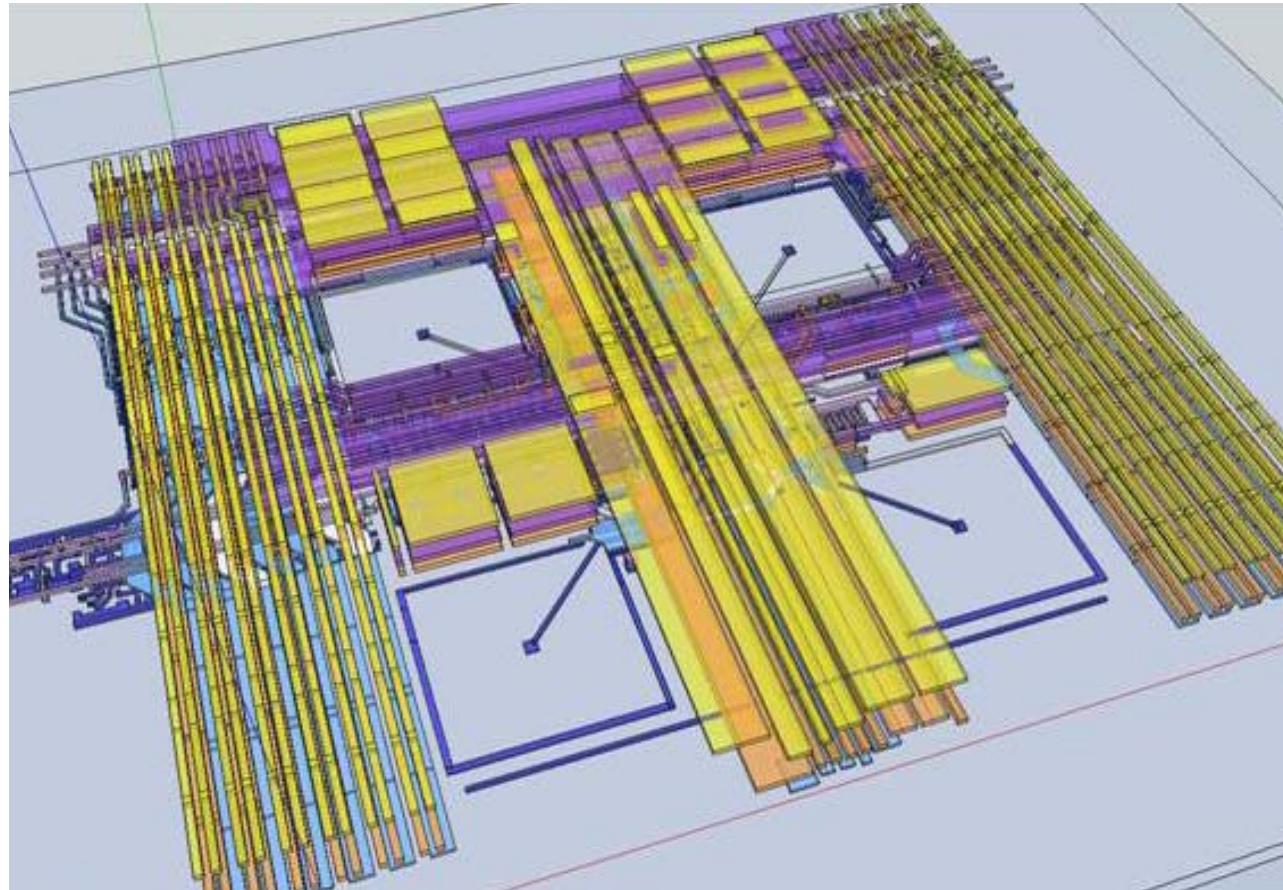
PImMS. A single particle CMOS Image Sensor.

PImMS – Pixel Imaging Mass Spectrometry





PImMS pixel layout



Over 600 transistors
per pixel

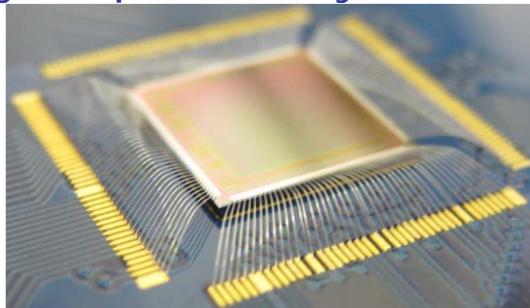
Modified process
developed with
TowerJazz: deep P-
implant for 100% fill
factor and true CMOS



PImMS family

PImMS1

72 by 72 pixel array



PIMMS USB camera



PImMS2

324 by 324 pixel array
70 µm x 70 µm pixel size

Time-code resolution
= 25 ns (12.5 demonstrated already
on PImMS1)

4 event stored in each pixel

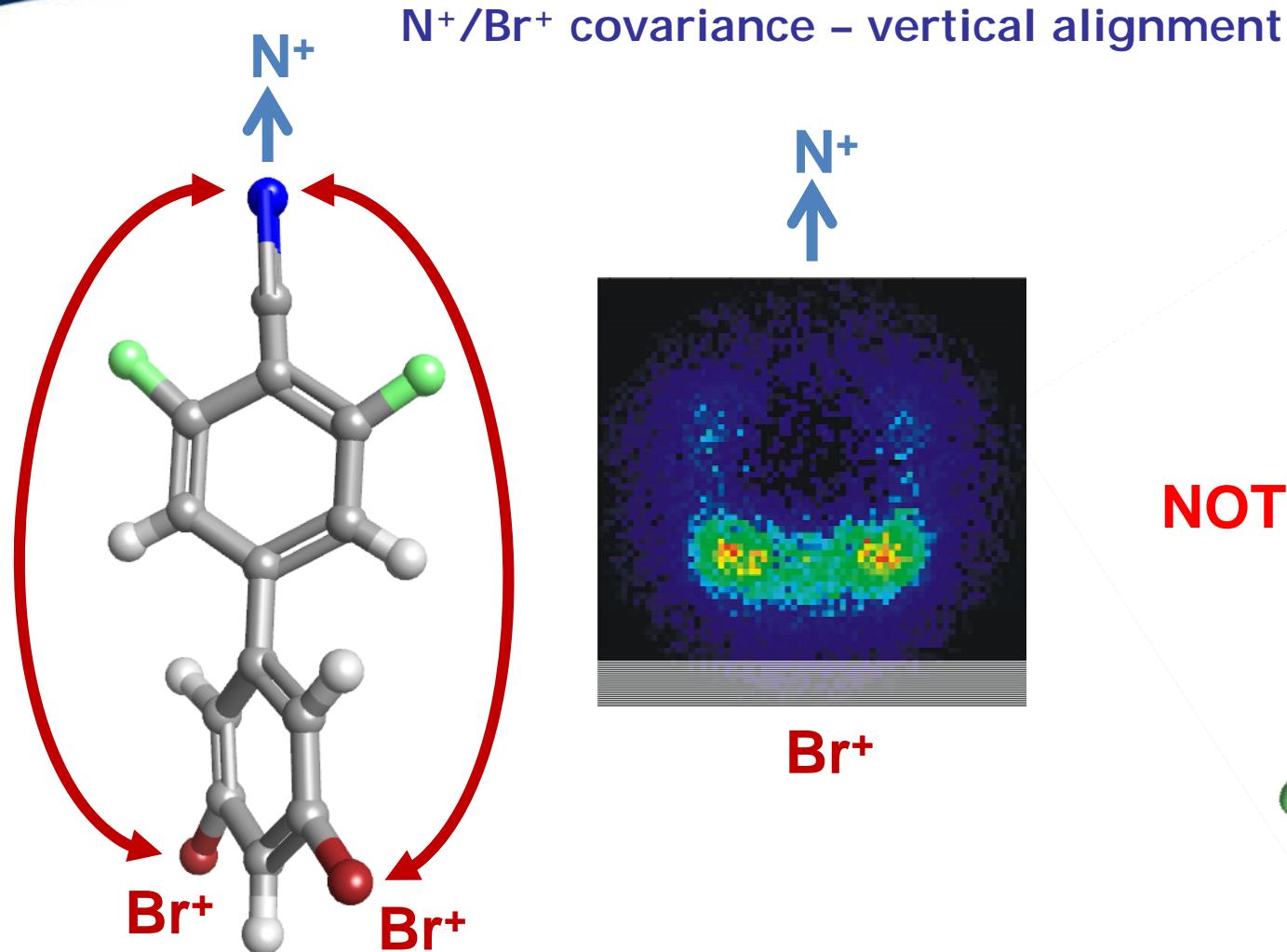
12 bit time-code resolution

Analogue readout of intensity
information

Equivalent pixel rate for standard full
frame camera



PImMS. First example of scientific results.





(Ultra)-High speed imaging. Applications

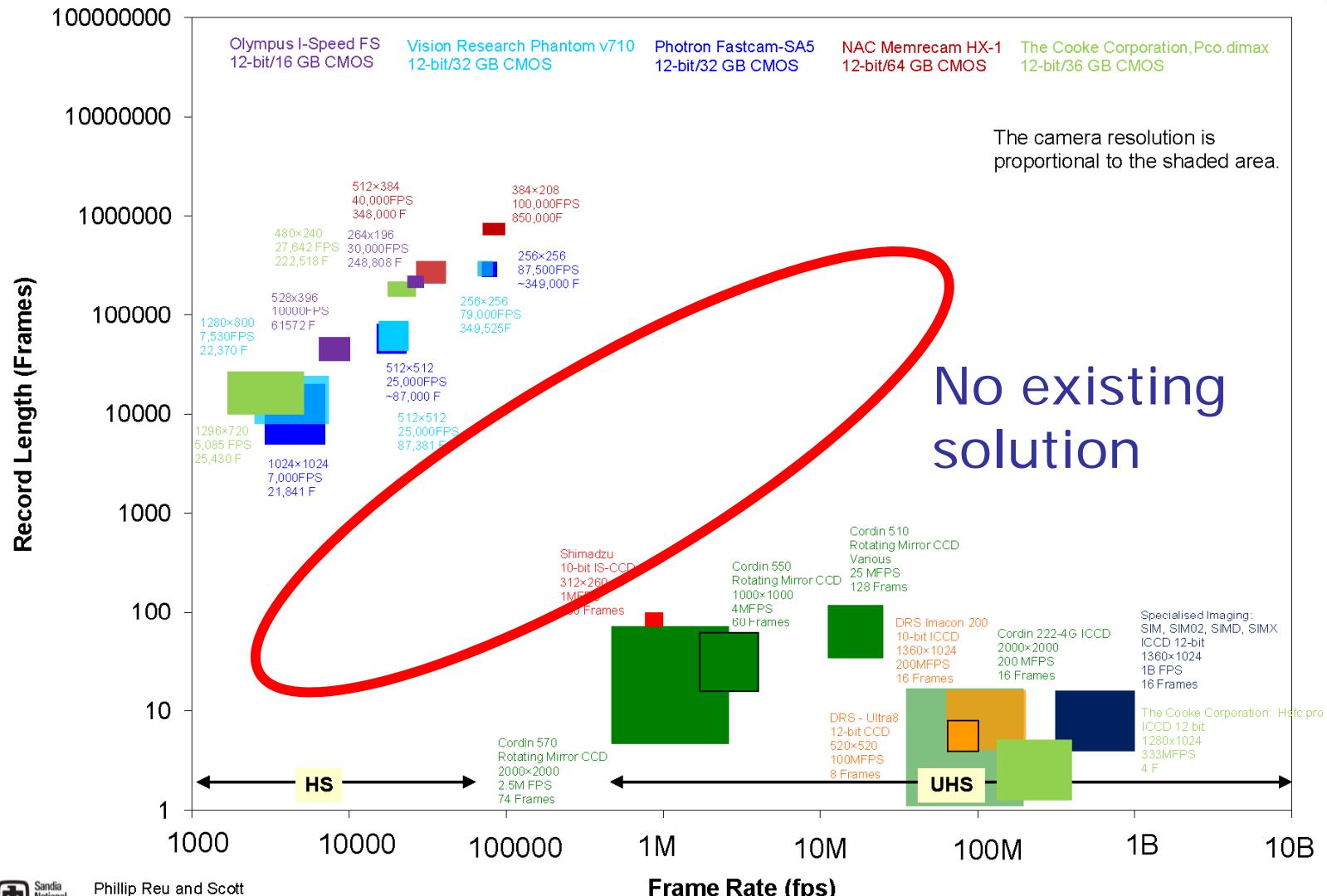
High-speed: 1k to 100kfps

Ultra-high speed: >~ 1M fps

- Combustion Research
- Biological/Microscopy
- Ballistics
- Mechanics
- Cavitation
- Material Research
- Aerospace
- Digital Image Correlation
- PIV



(Ultra)-High speed imaging review





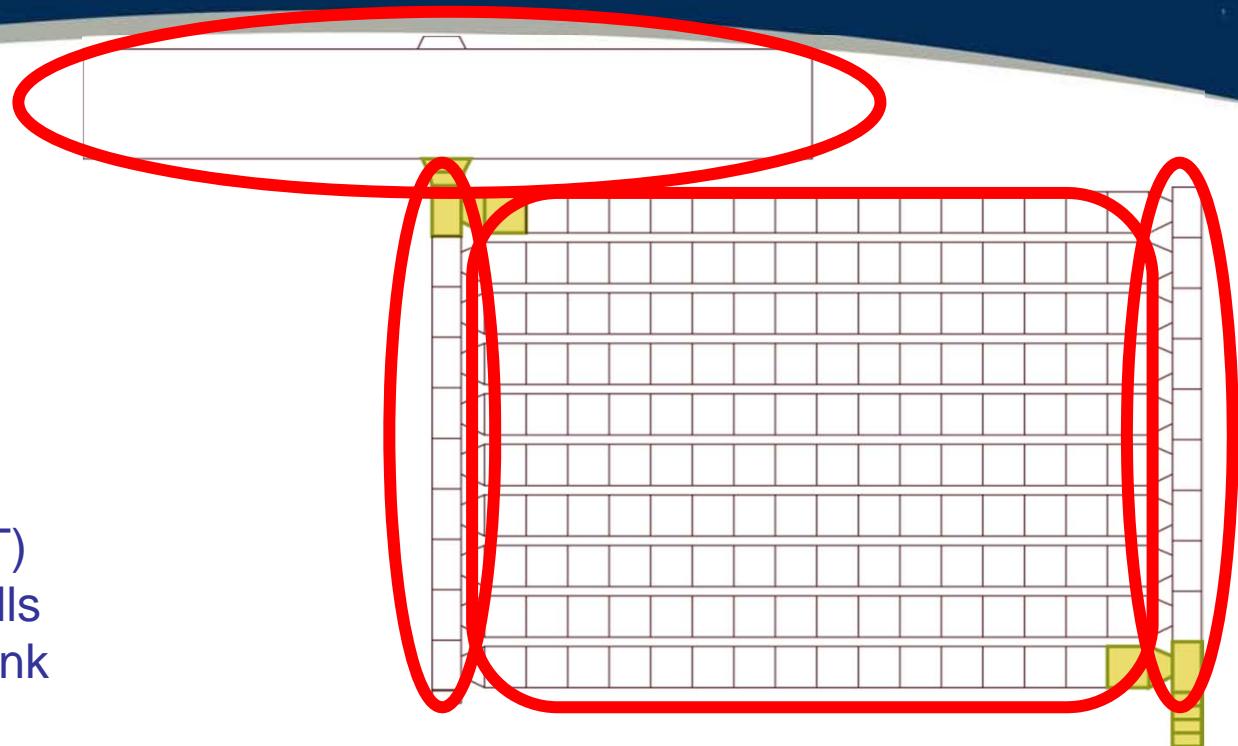
- CMOS for ease of use and readout speed
- Start from Tower 180 nm CIS process with dual gate oxide: 3nm + 10nm
- Optimise process for high-speed, high-efficiency charge transfer
- CCD for in-pixel storage



Photodiode

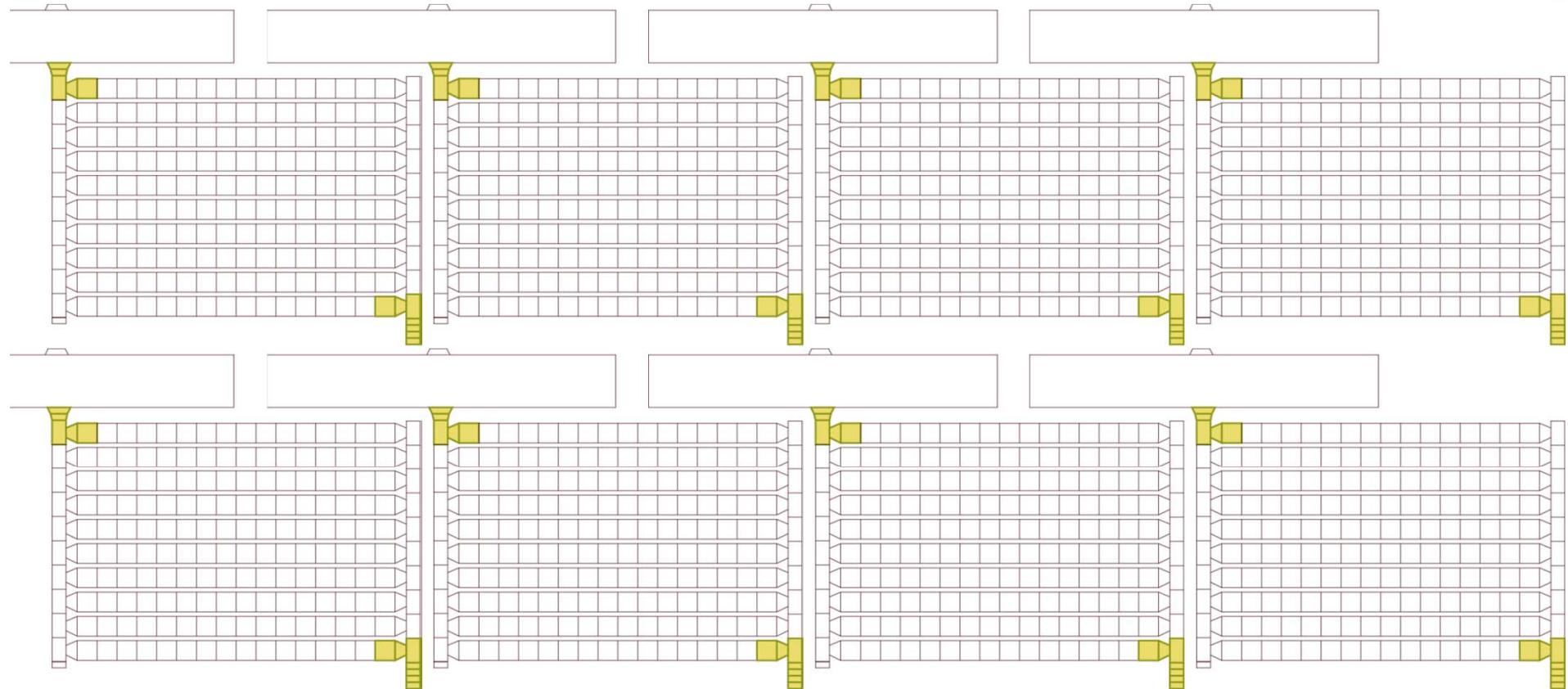
Memory bank

- A vertical entry (VEN) bank with 10 cells
- Ten rows of lateral (LAT) banks, each with 16 cells
- A vertical exit (VEX) bank with 10 cells
- Total of 180 memory cells





Kirana pixel. 2

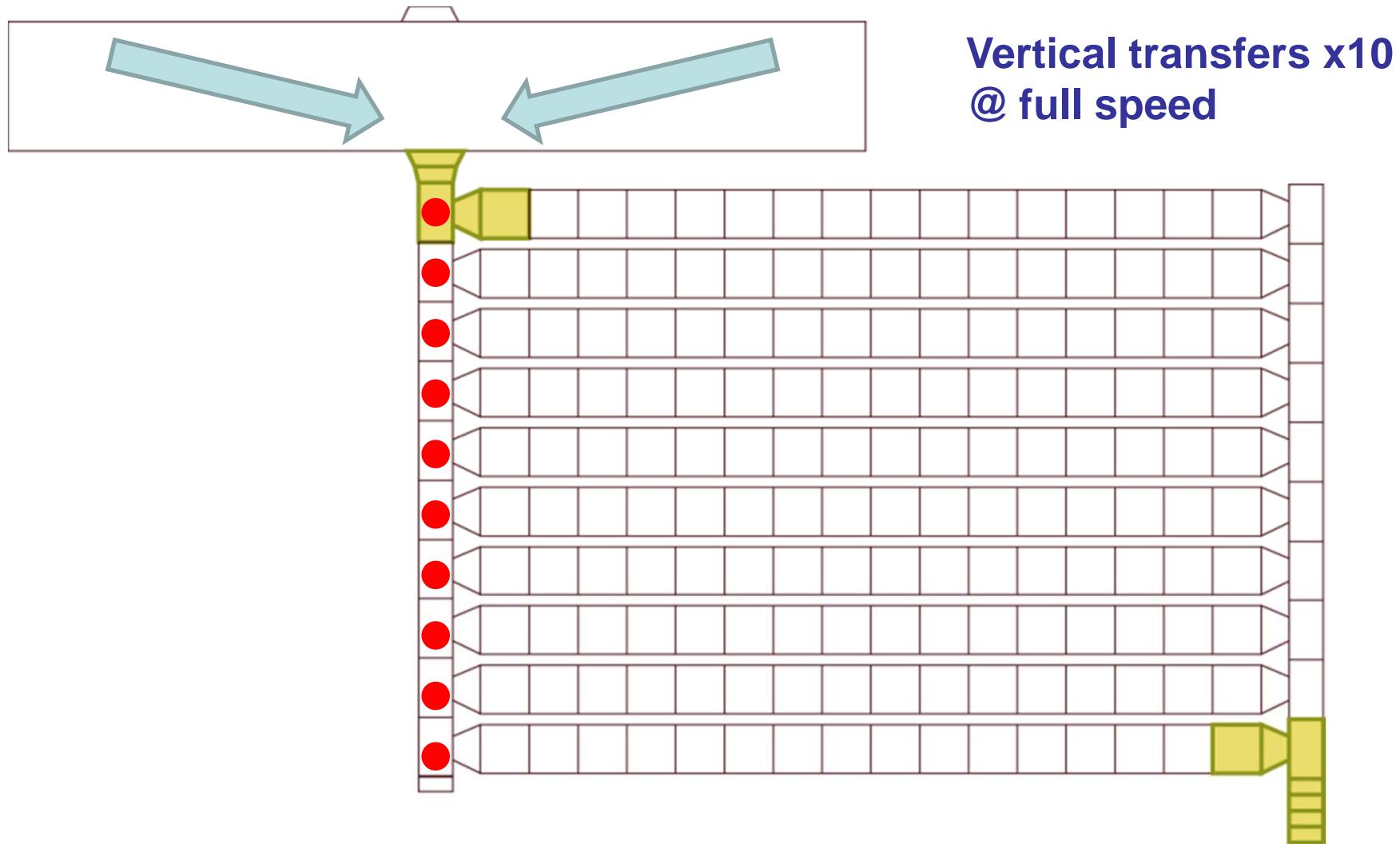


Highly scalable architecture:

- Number of memory cells
- Number of pixels



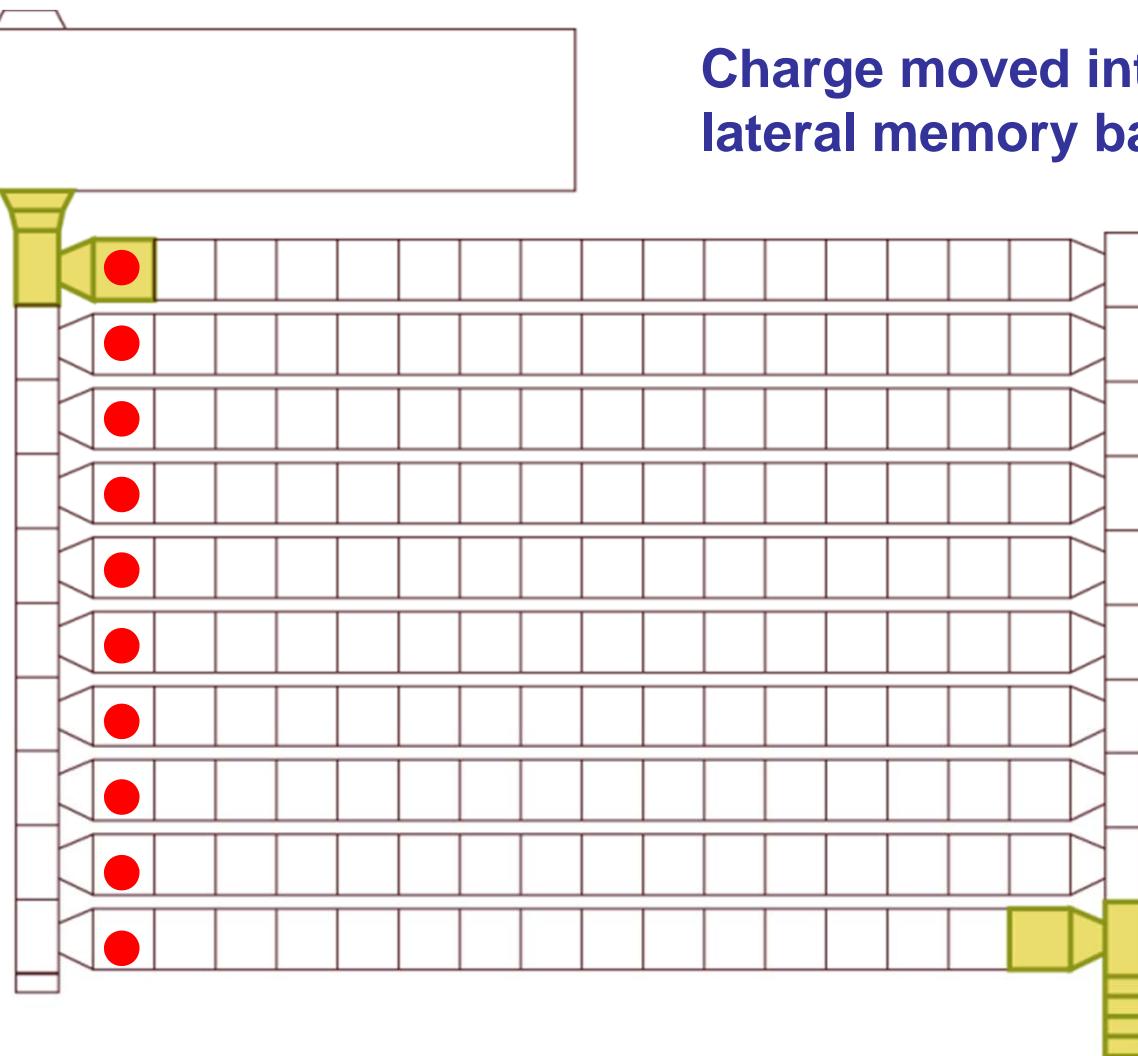
Burst mode





Burst mode

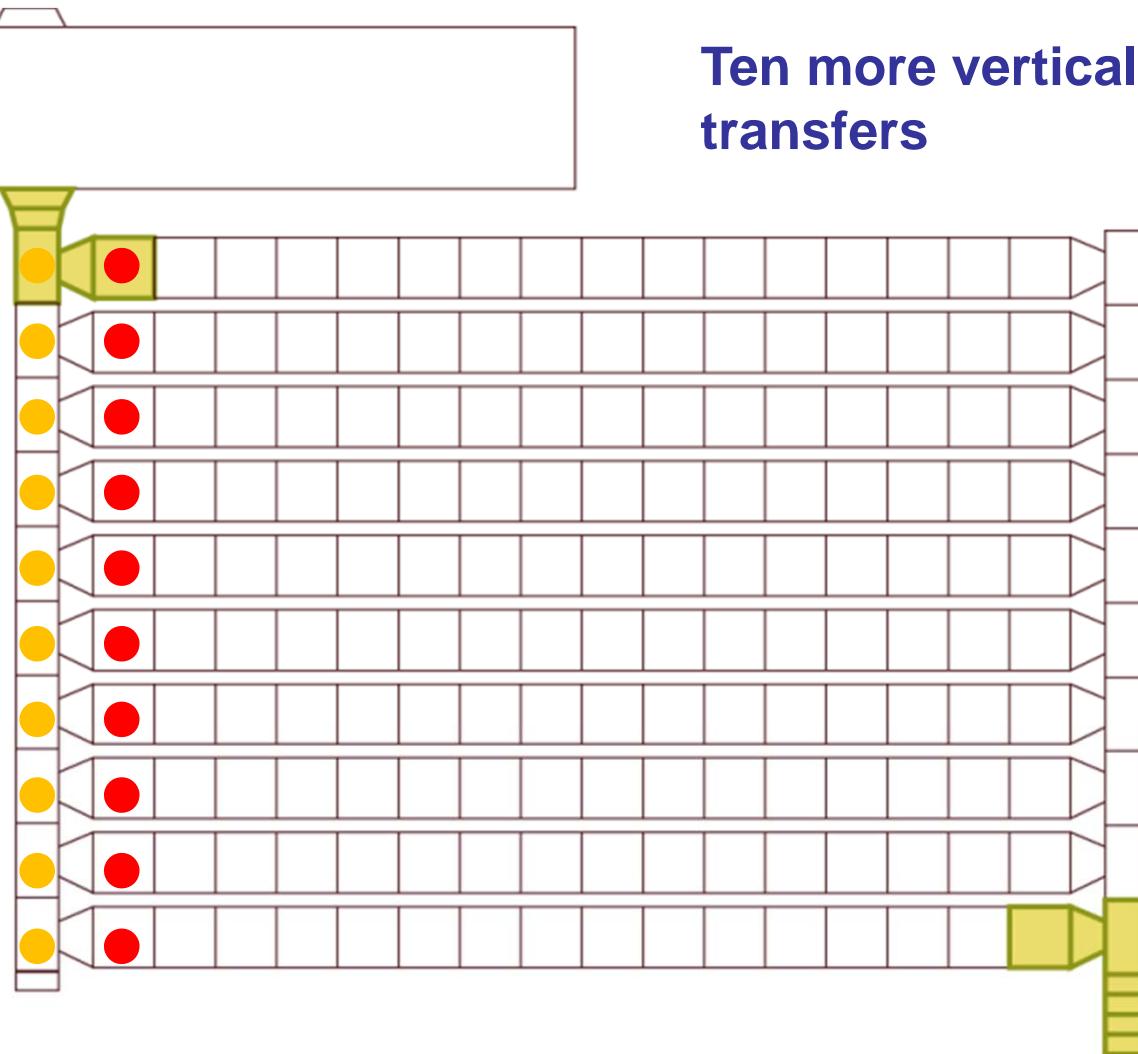
Charge moved into
lateral memory bank





Burst mode

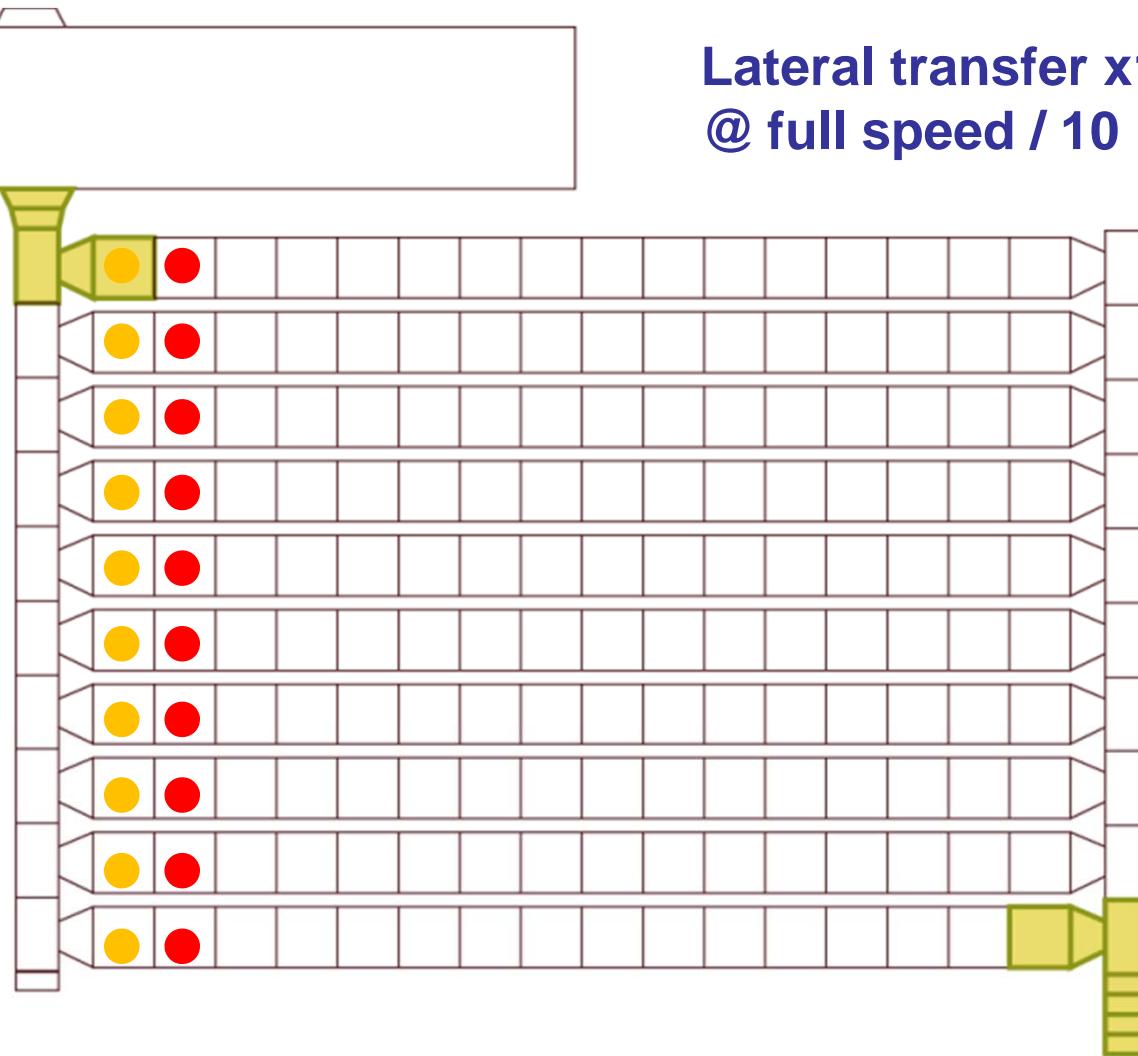
Ten more vertical transfers





Burst mode

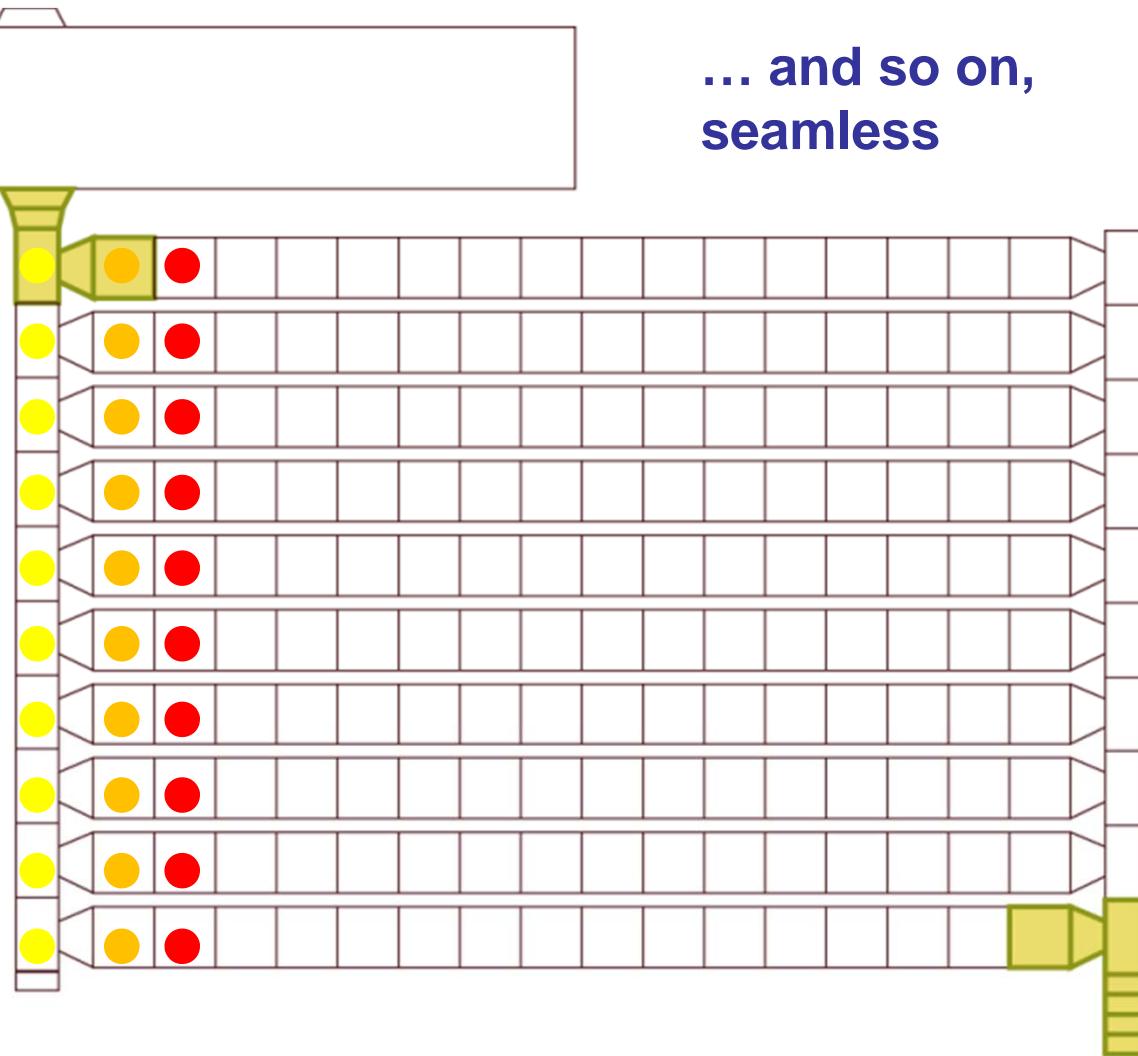
Lateral transfer x1
@ full speed / 10





Burst mode

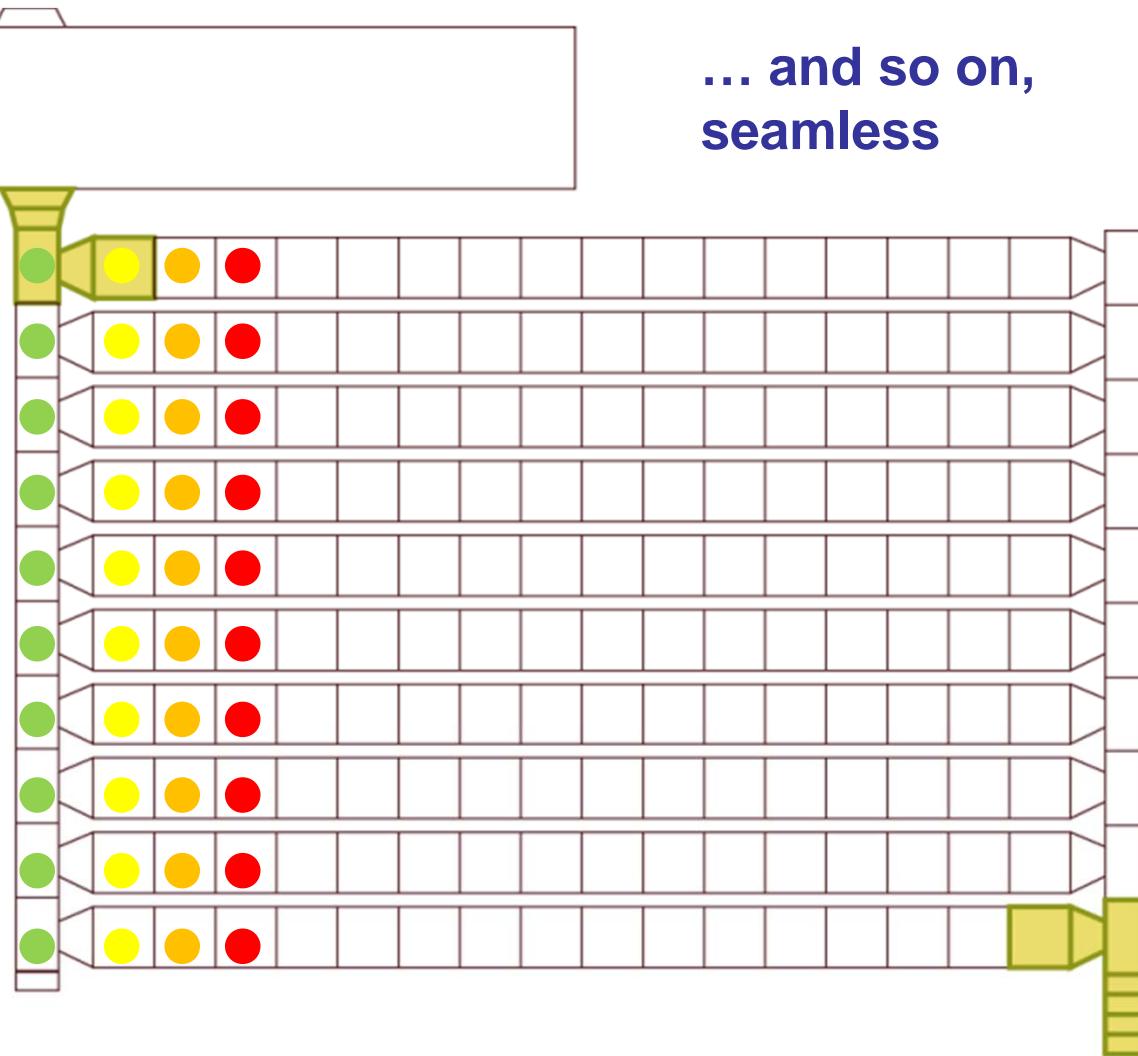
... and so on,
seamless





Burst mode

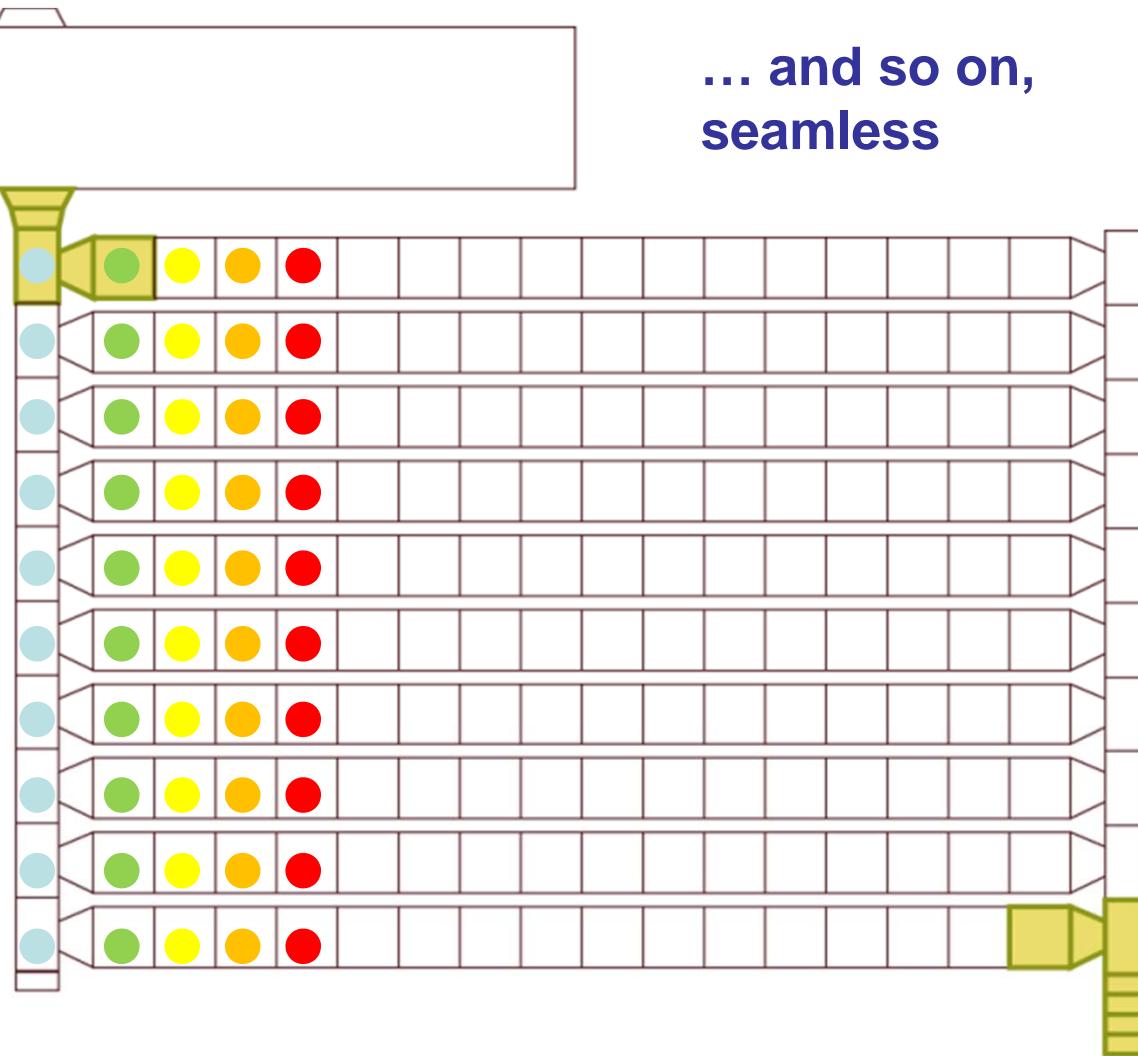
... and so on,
seamless





Burst mode

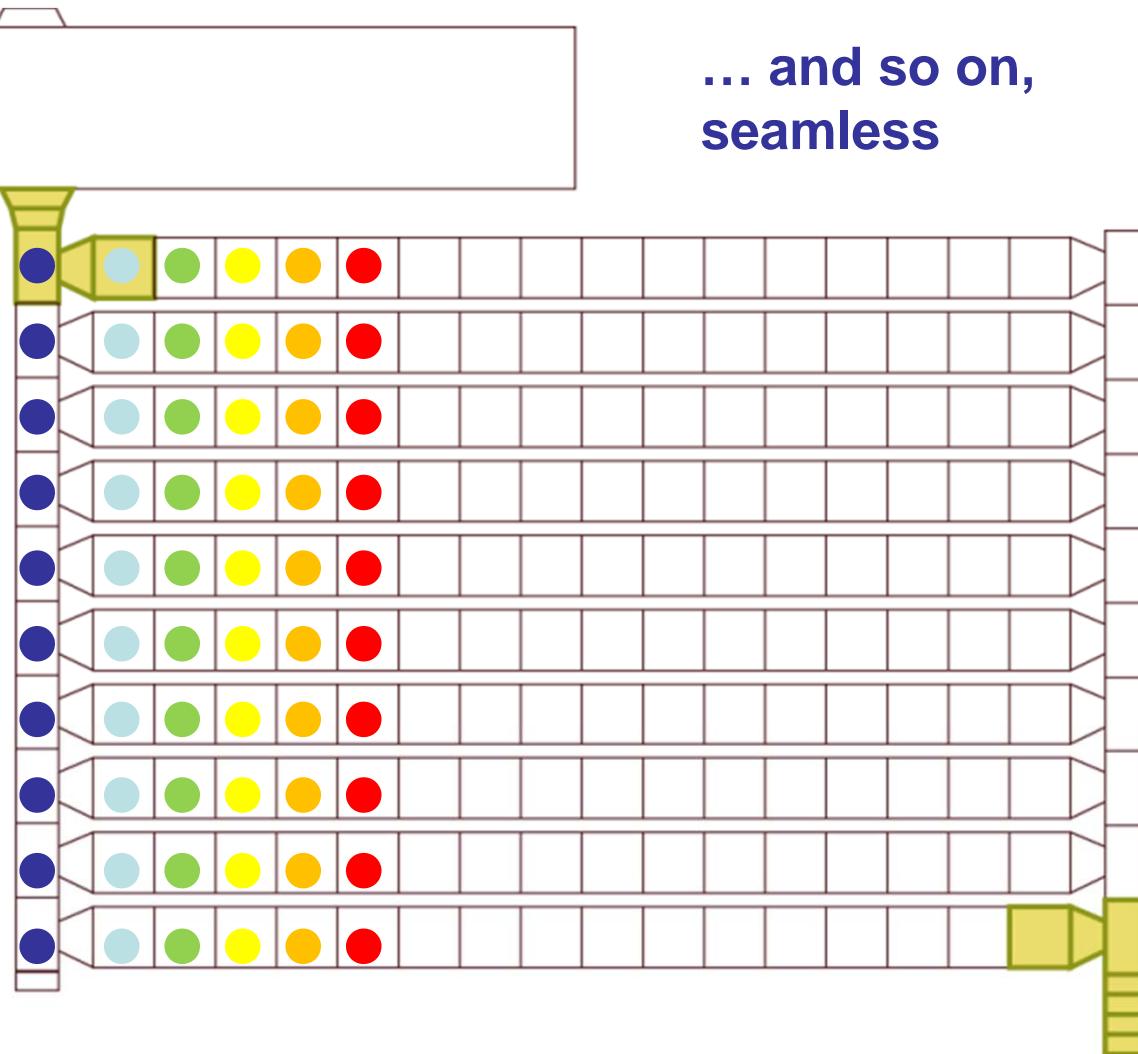
... and so on,
seamless





Burst mode

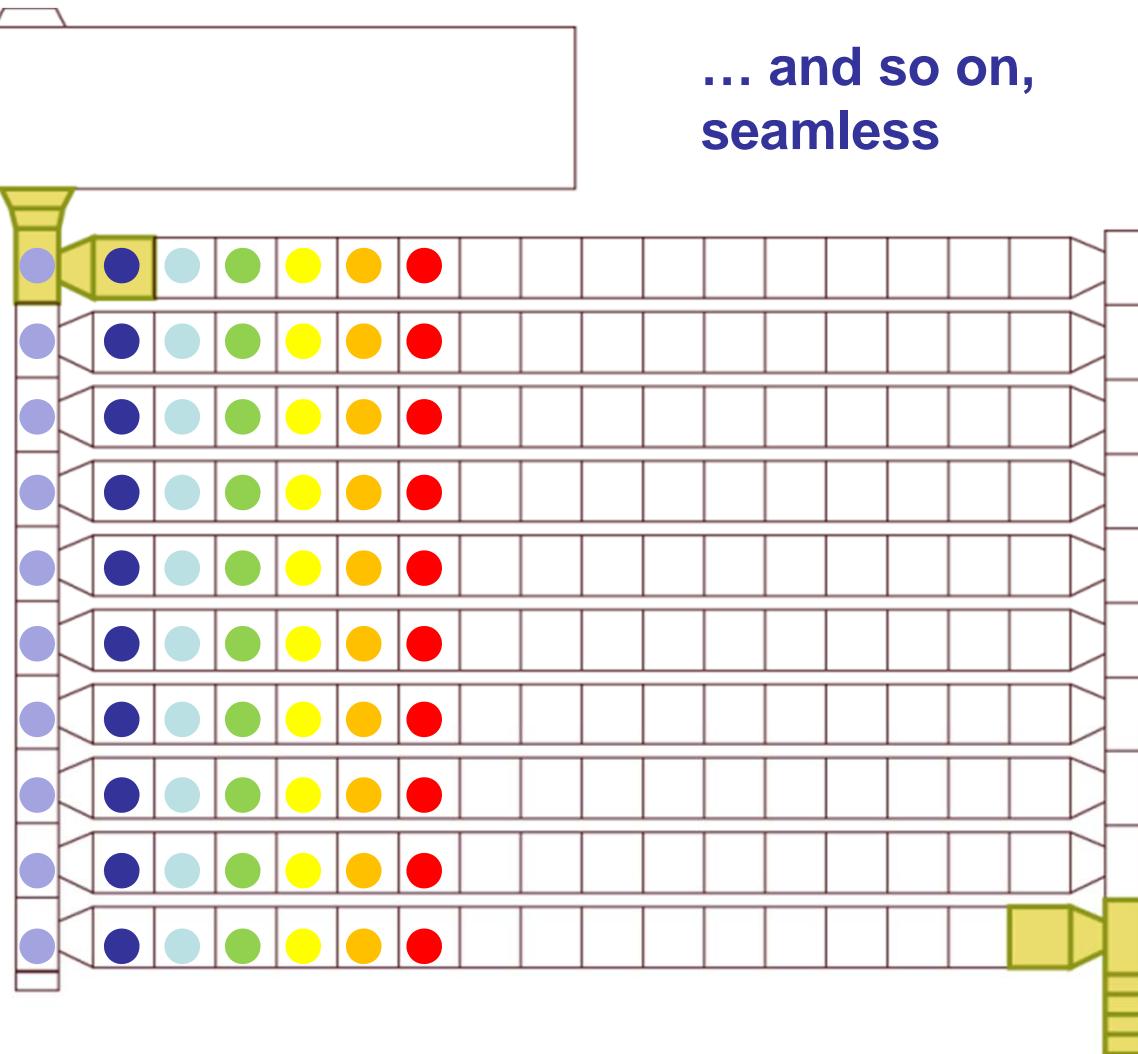
... and so on,
seamless





Burst mode

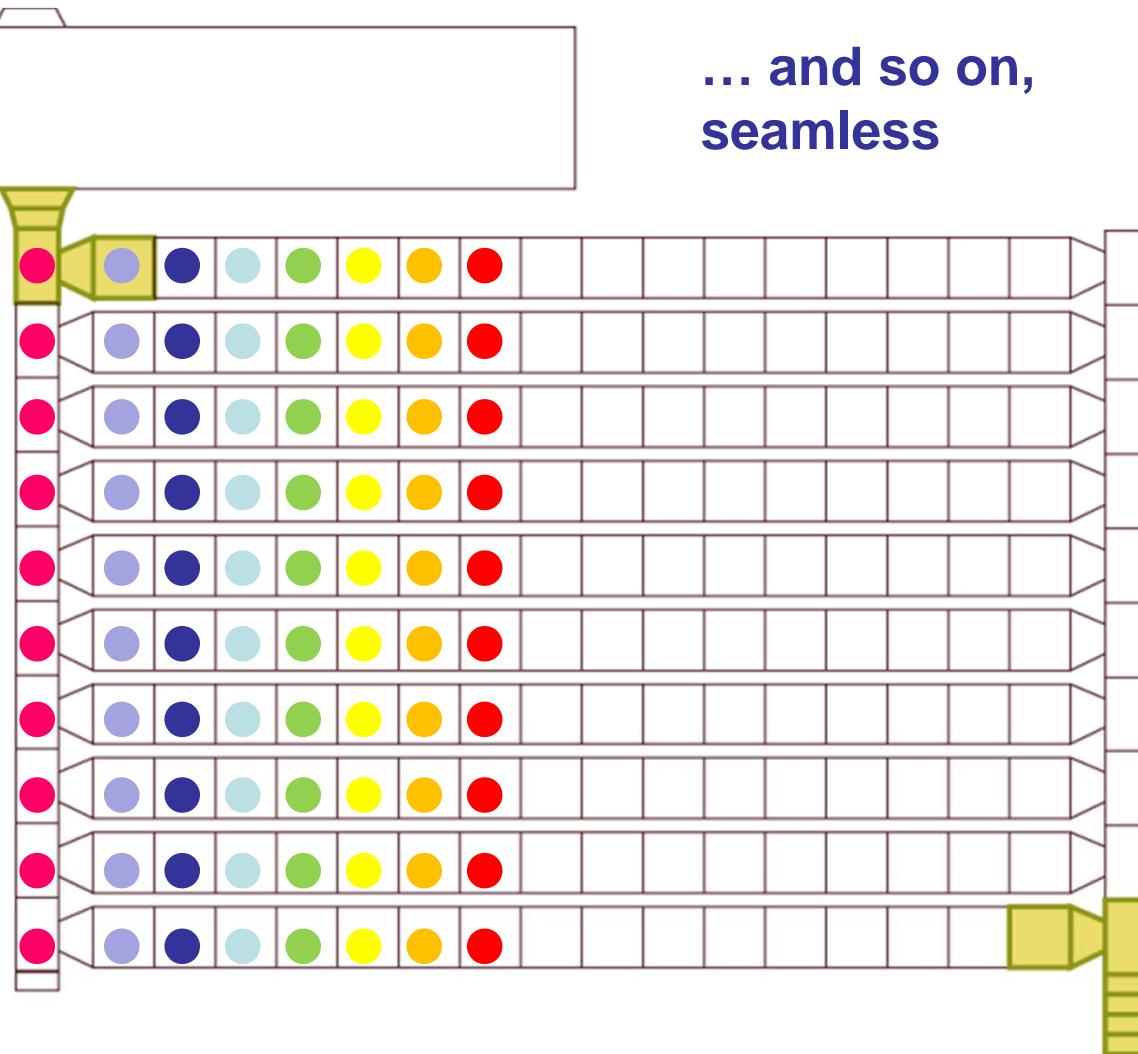
... and so on,
seamless





Burst mode

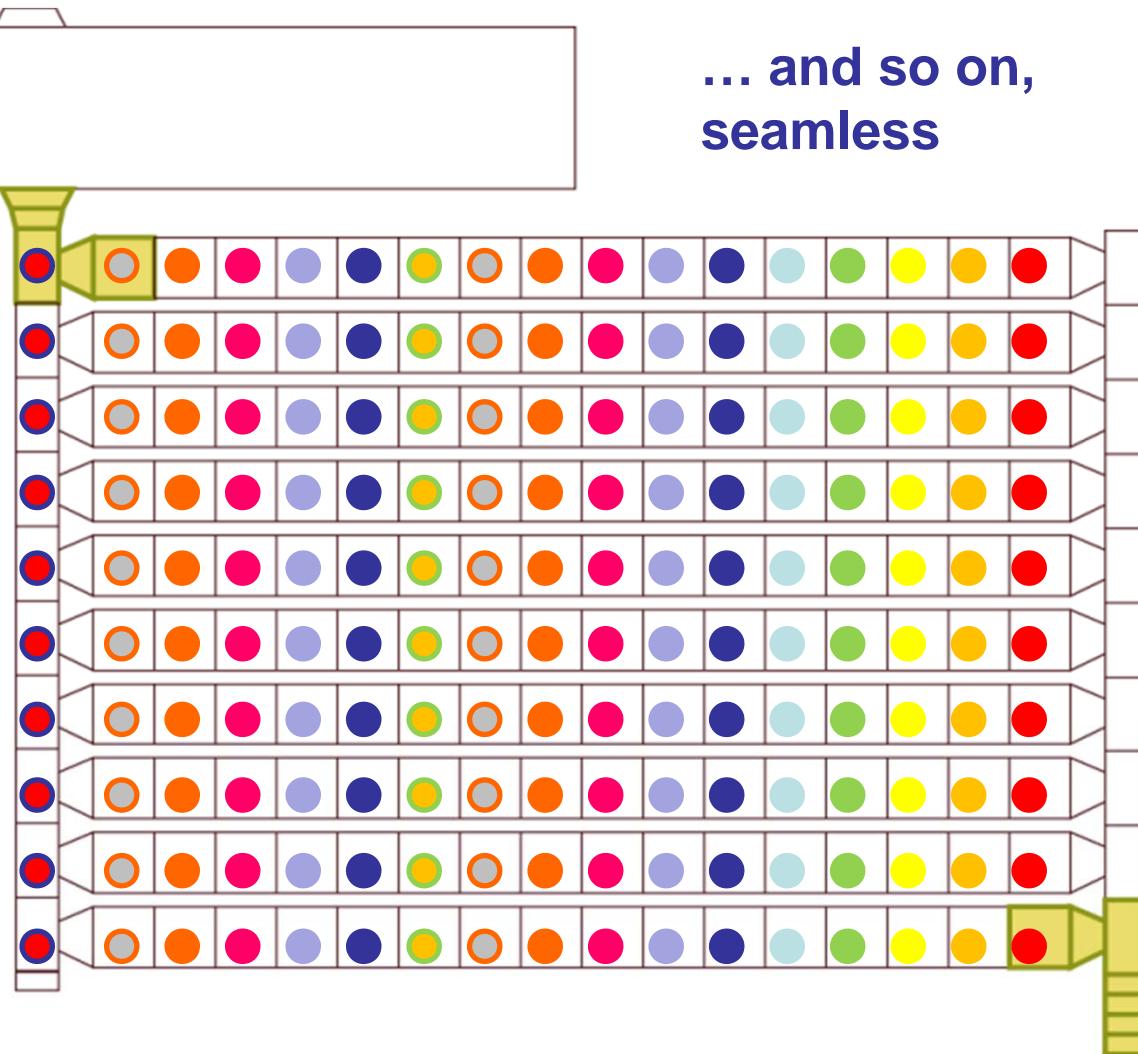
... and so on,
seamless





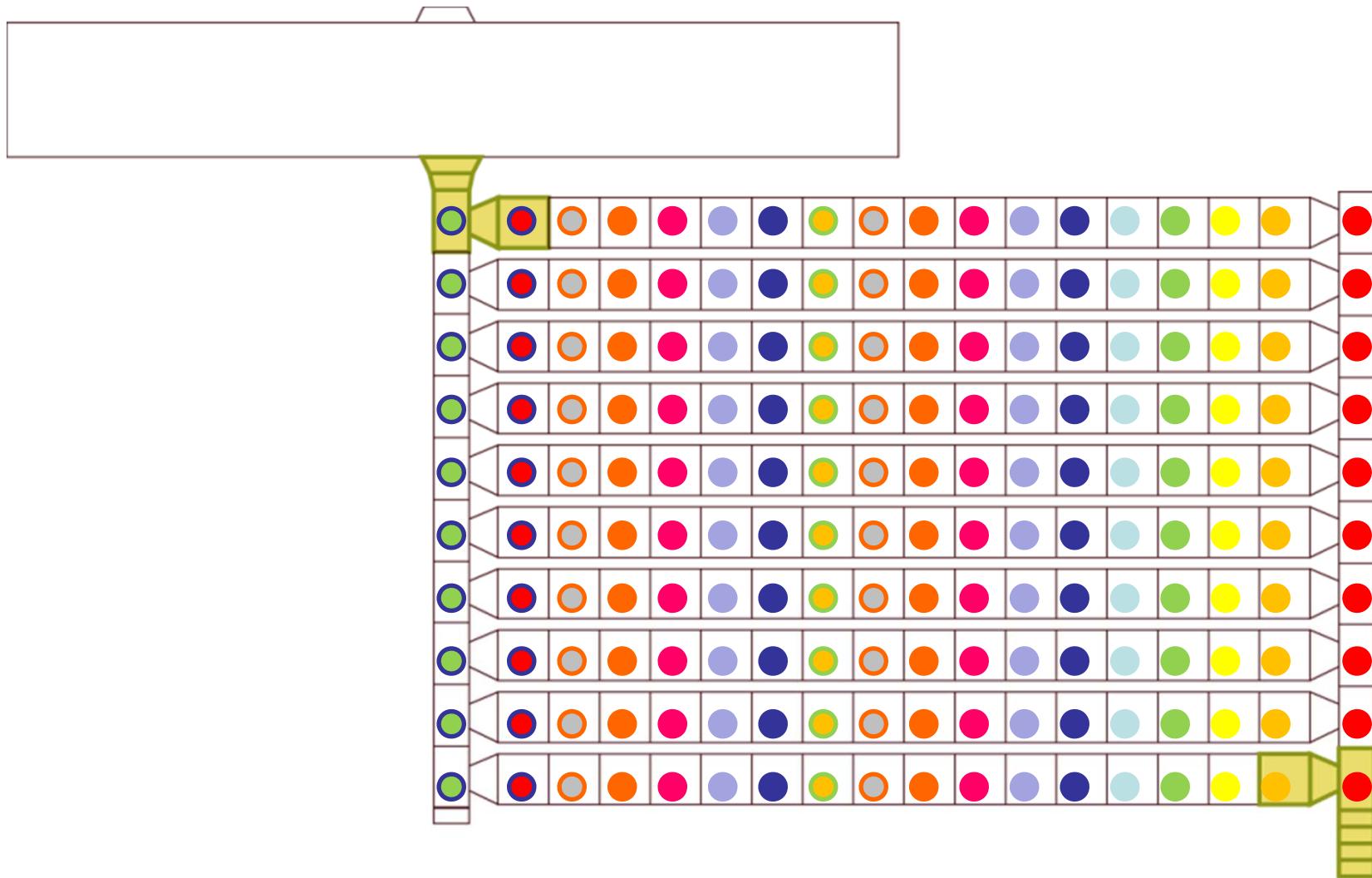
Burst mode

... and so on,
seamless





Burst mode



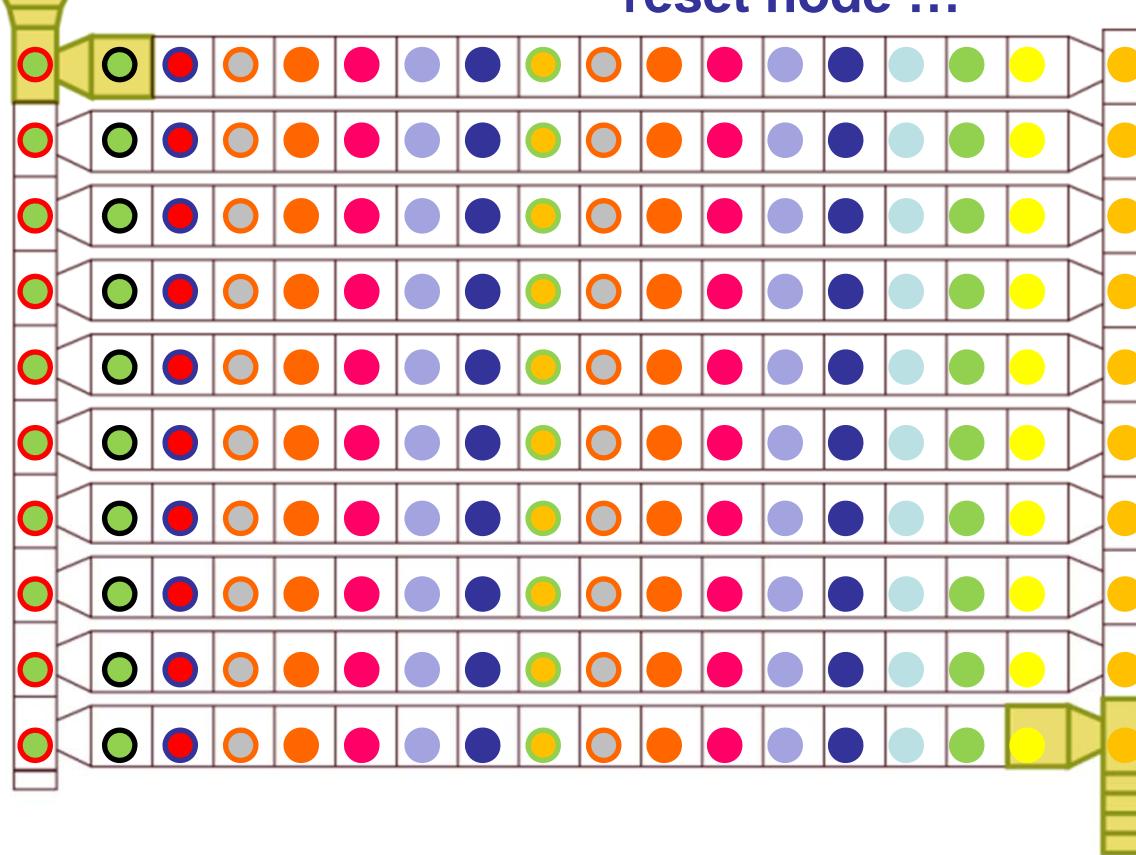


Burst mode



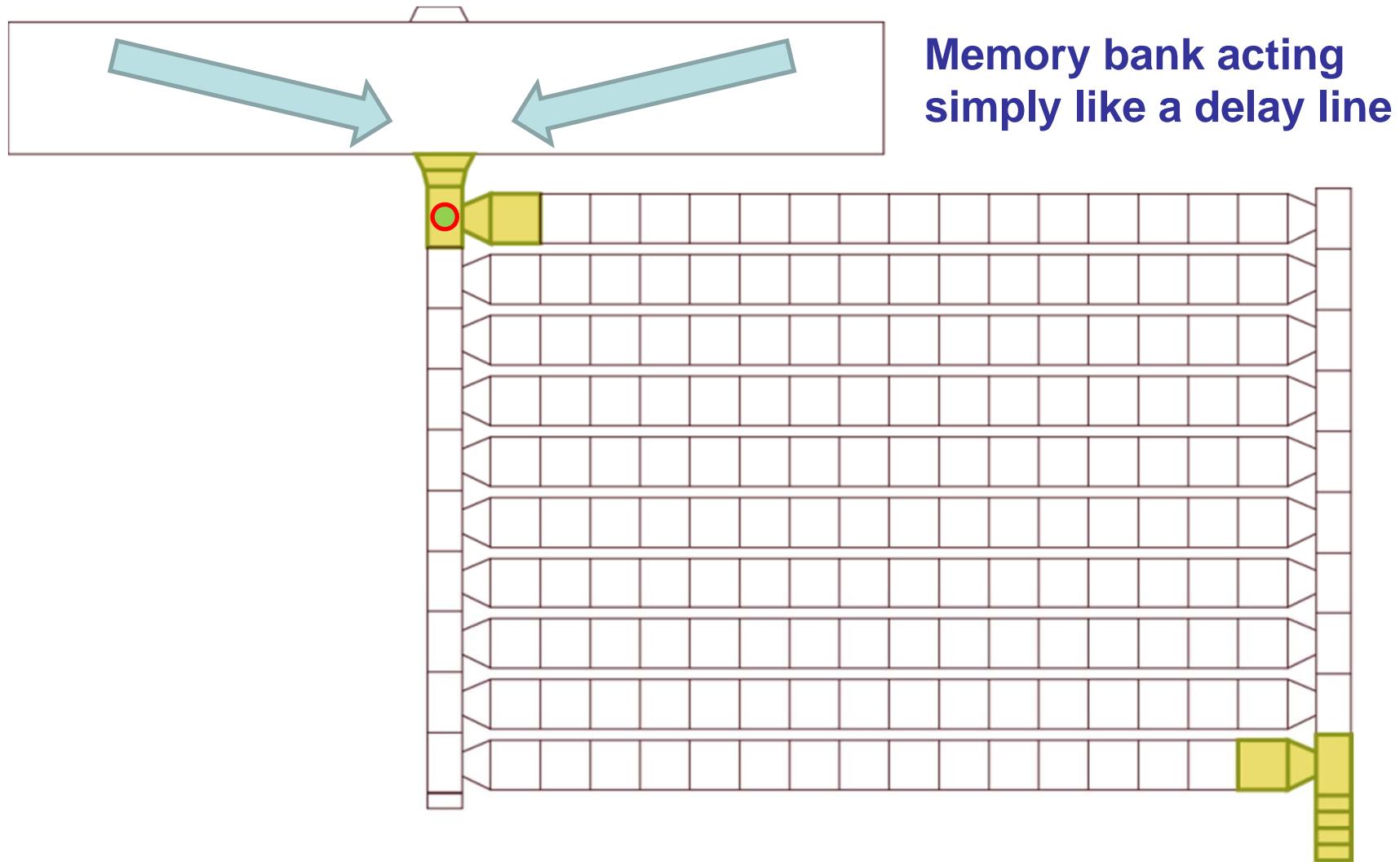
... until receipt
of the trigger.
The status of
the memory
bank is then
frozen and the
sensor read
out.

Charge in the vertical exit
registers is dumped in the
reset node ...



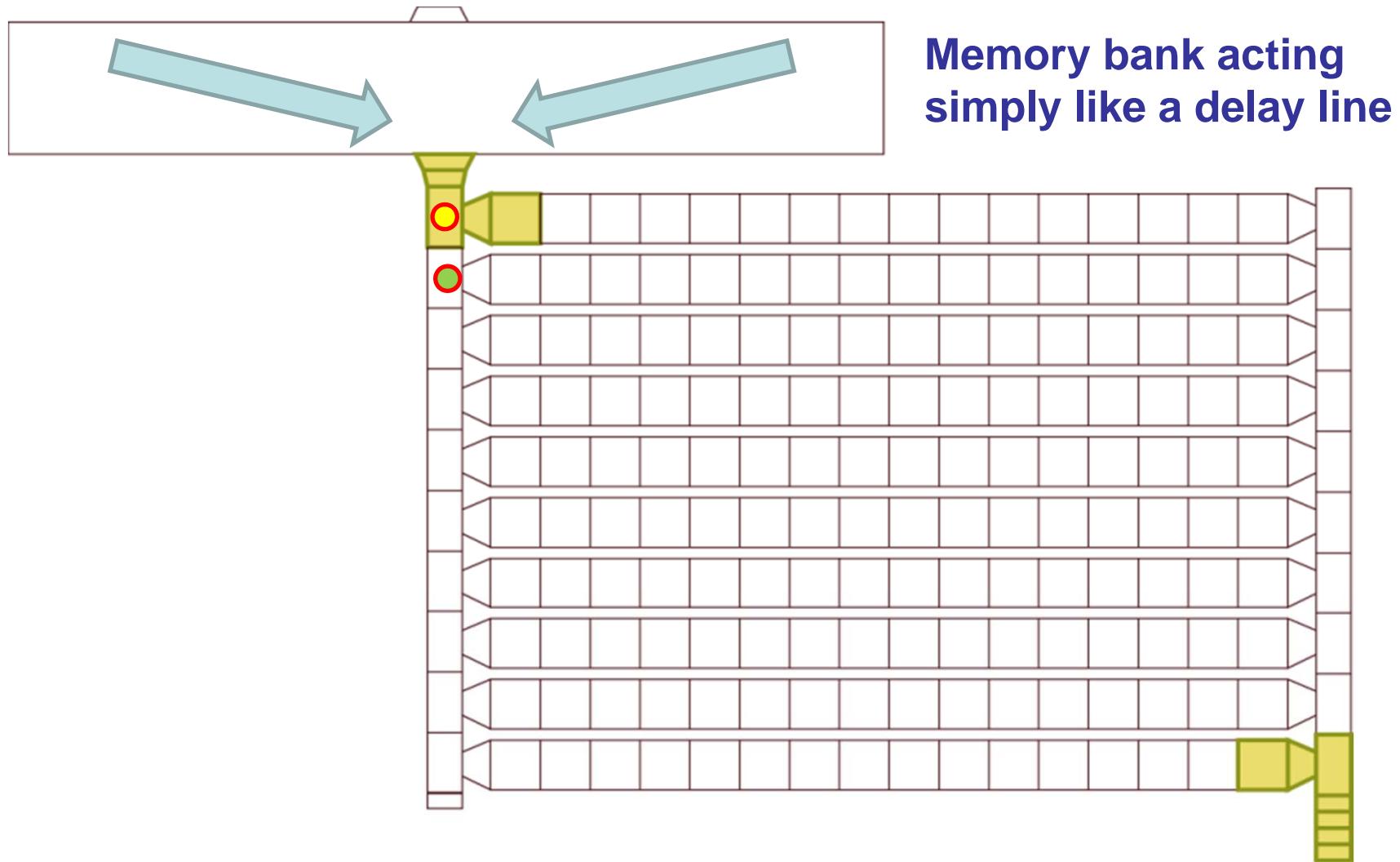


Continuous mode



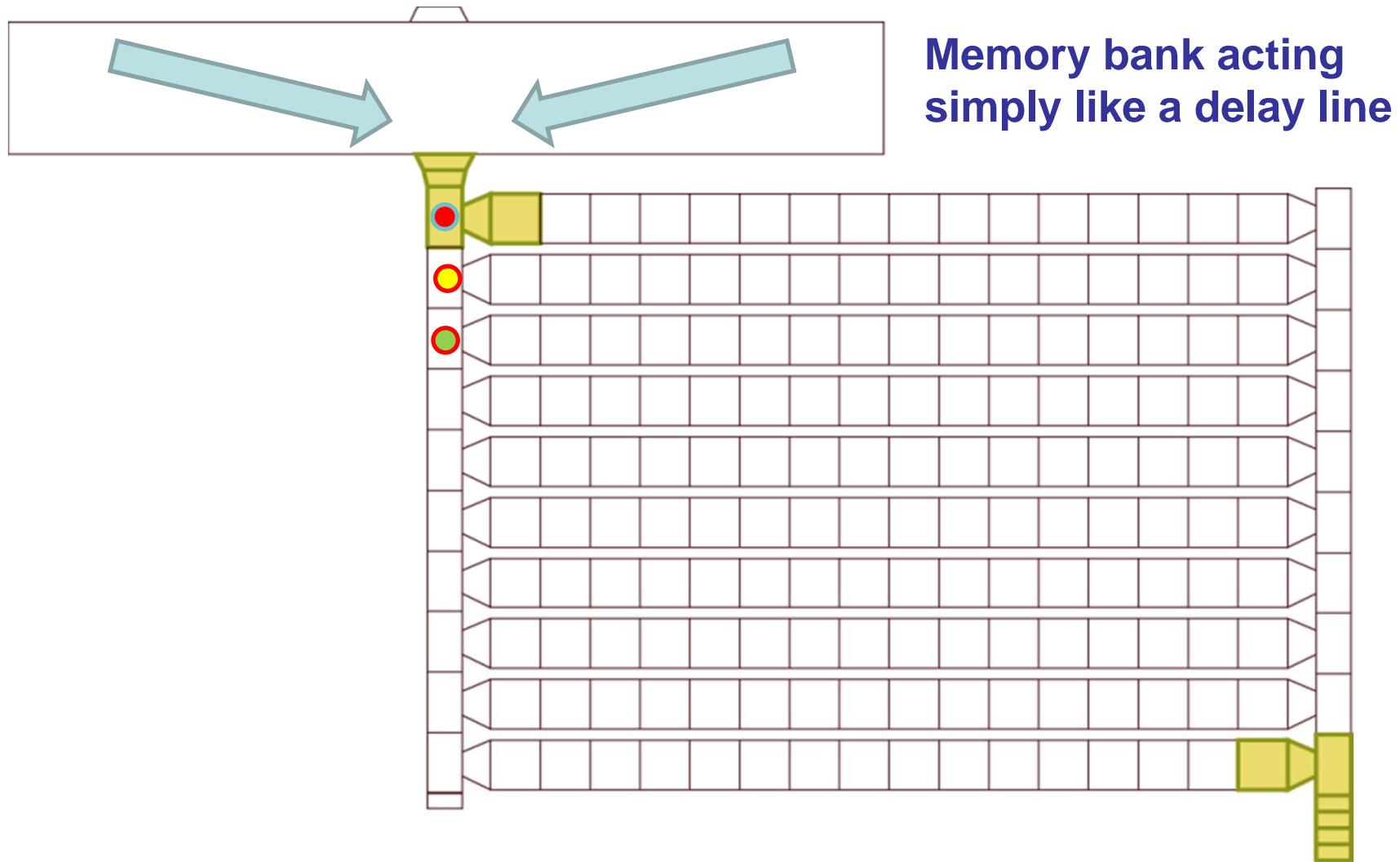


Continuous mode



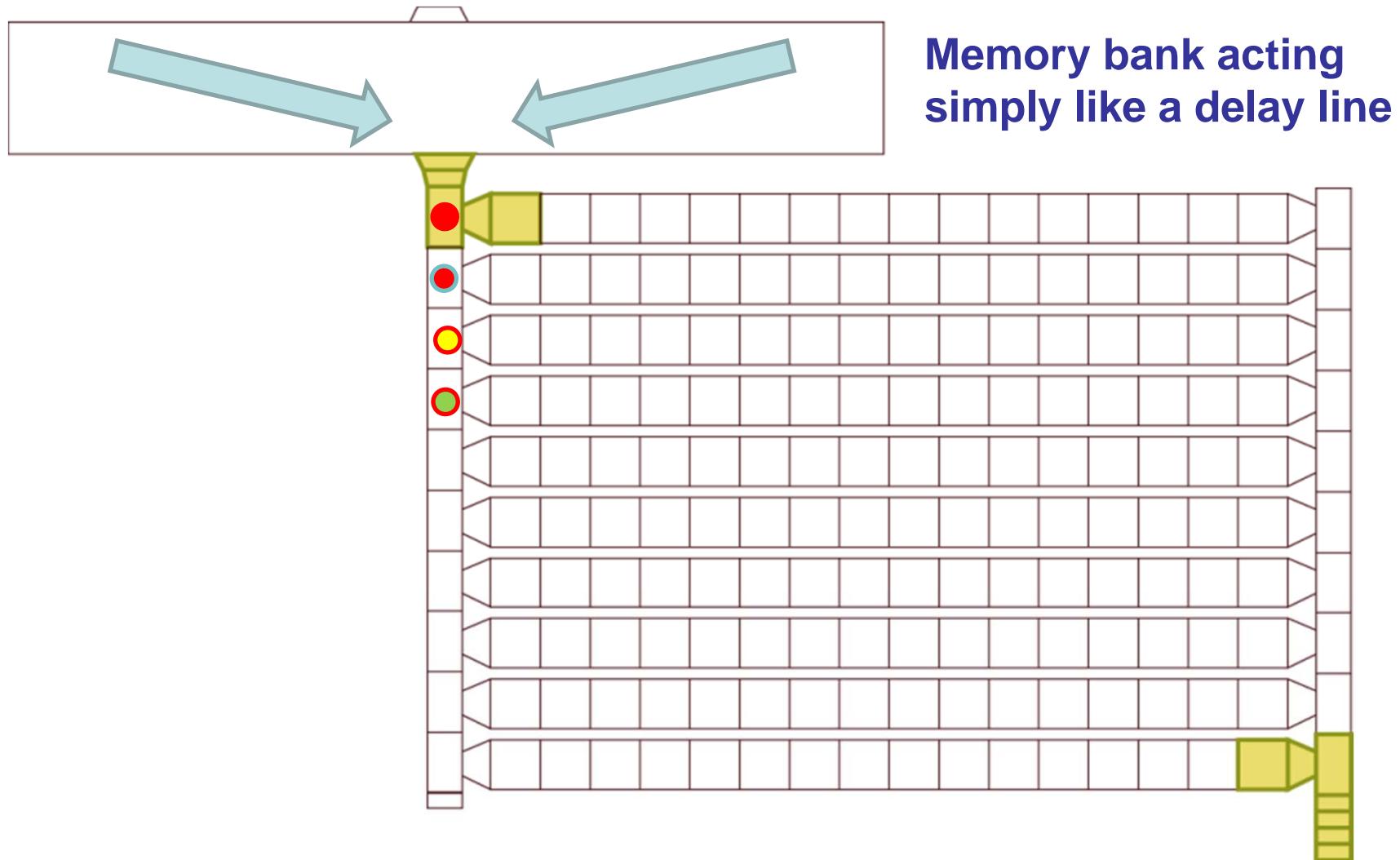


Continuous mode



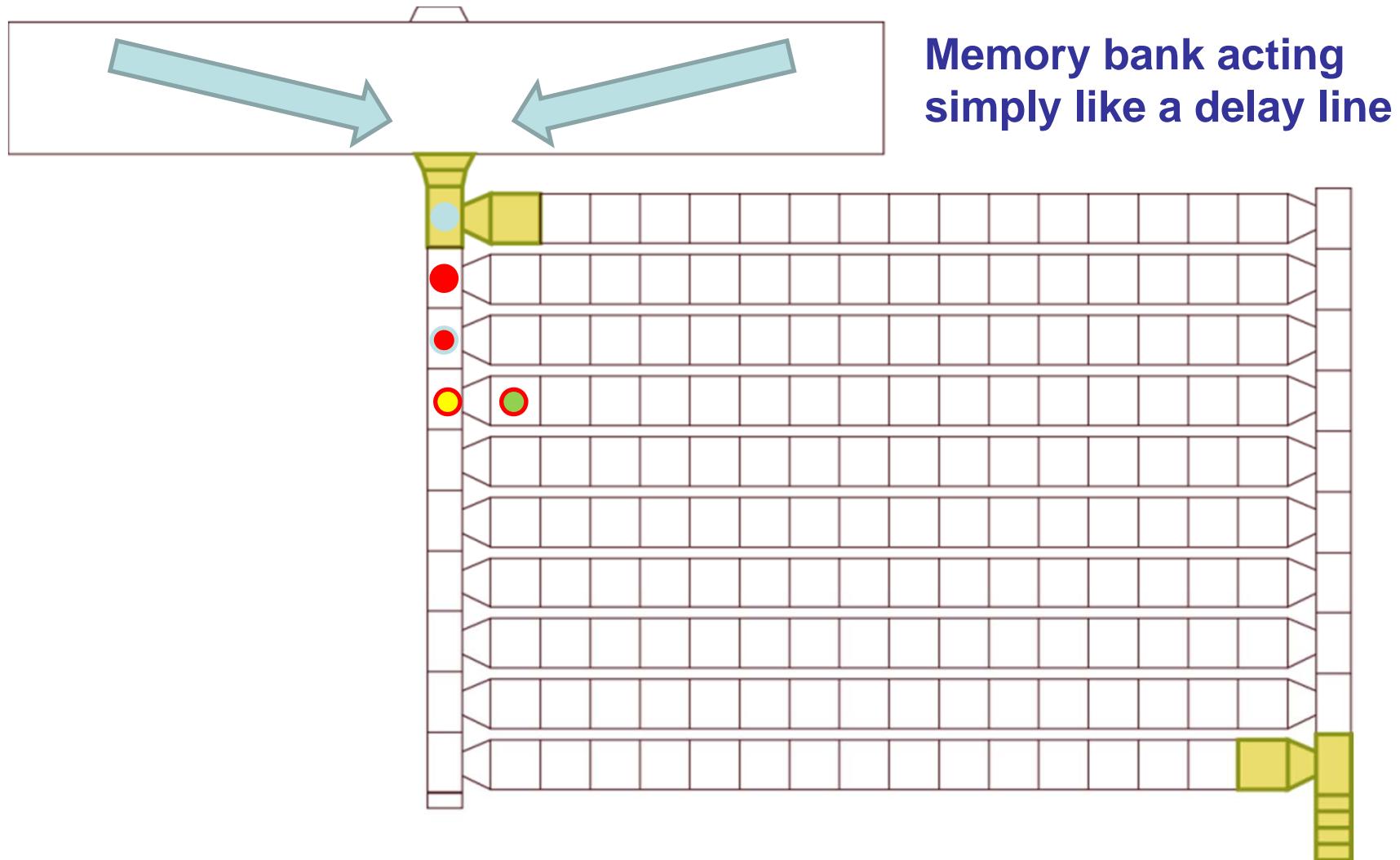


Continuous mode



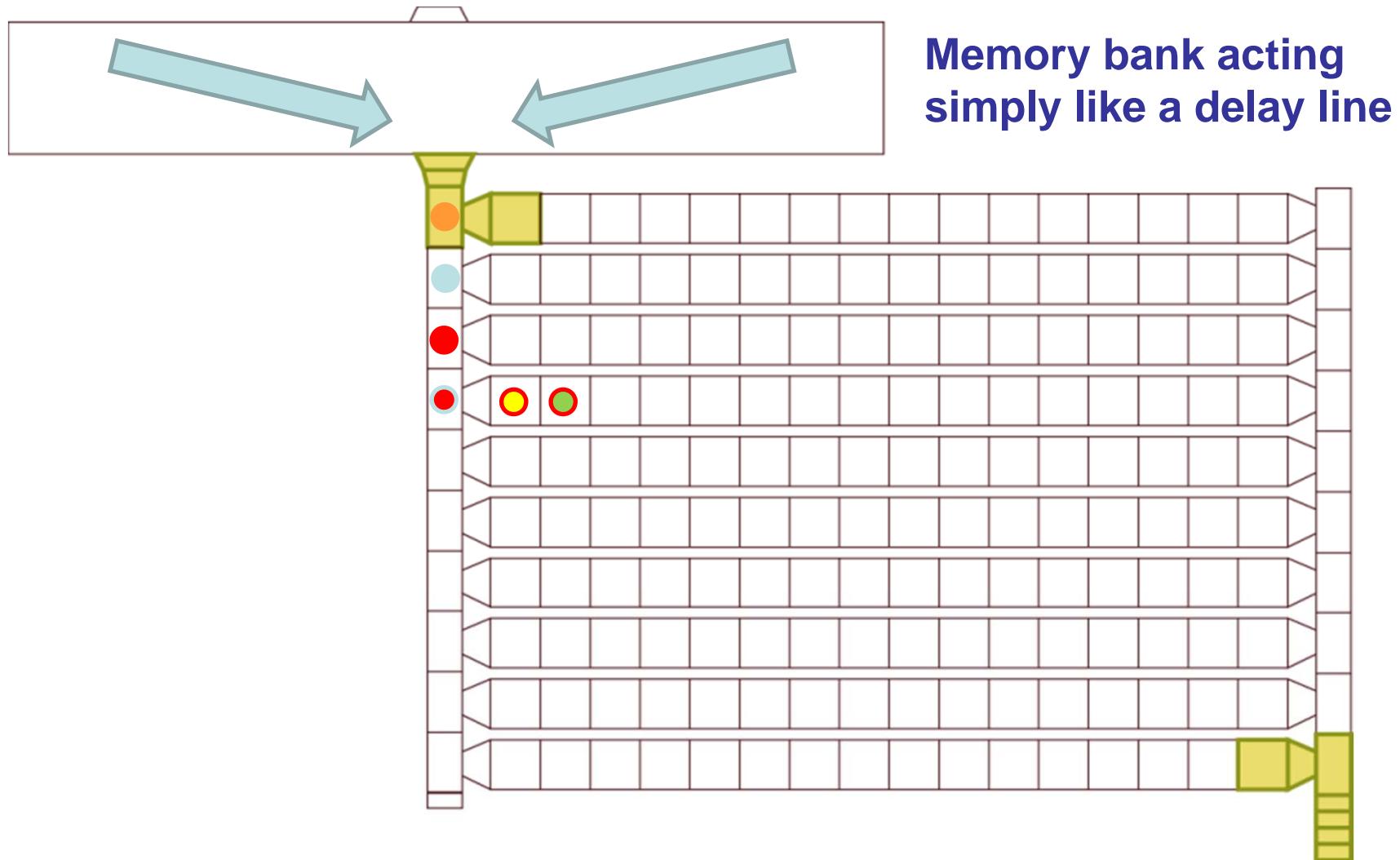


Continuous mode



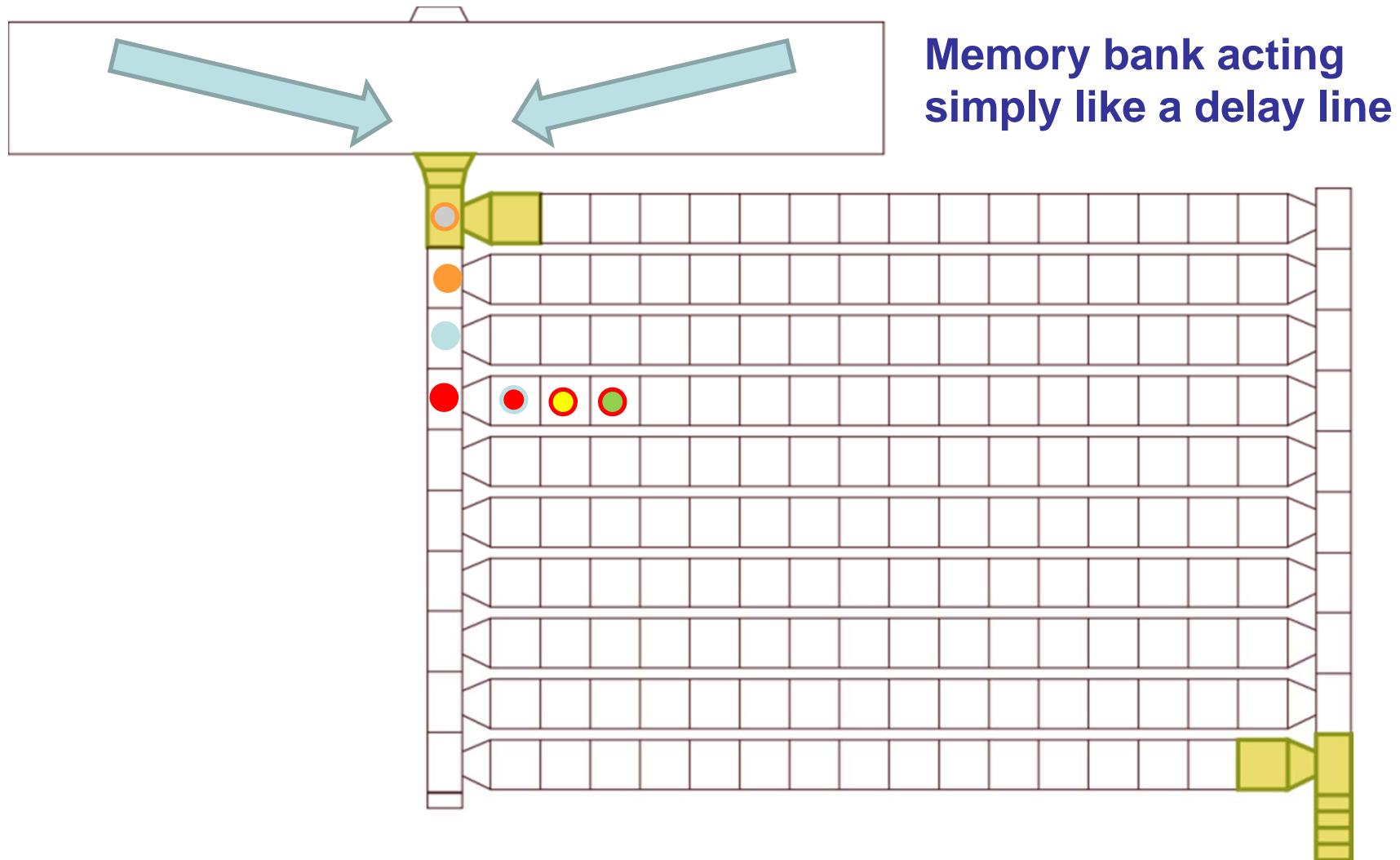


Continuous mode



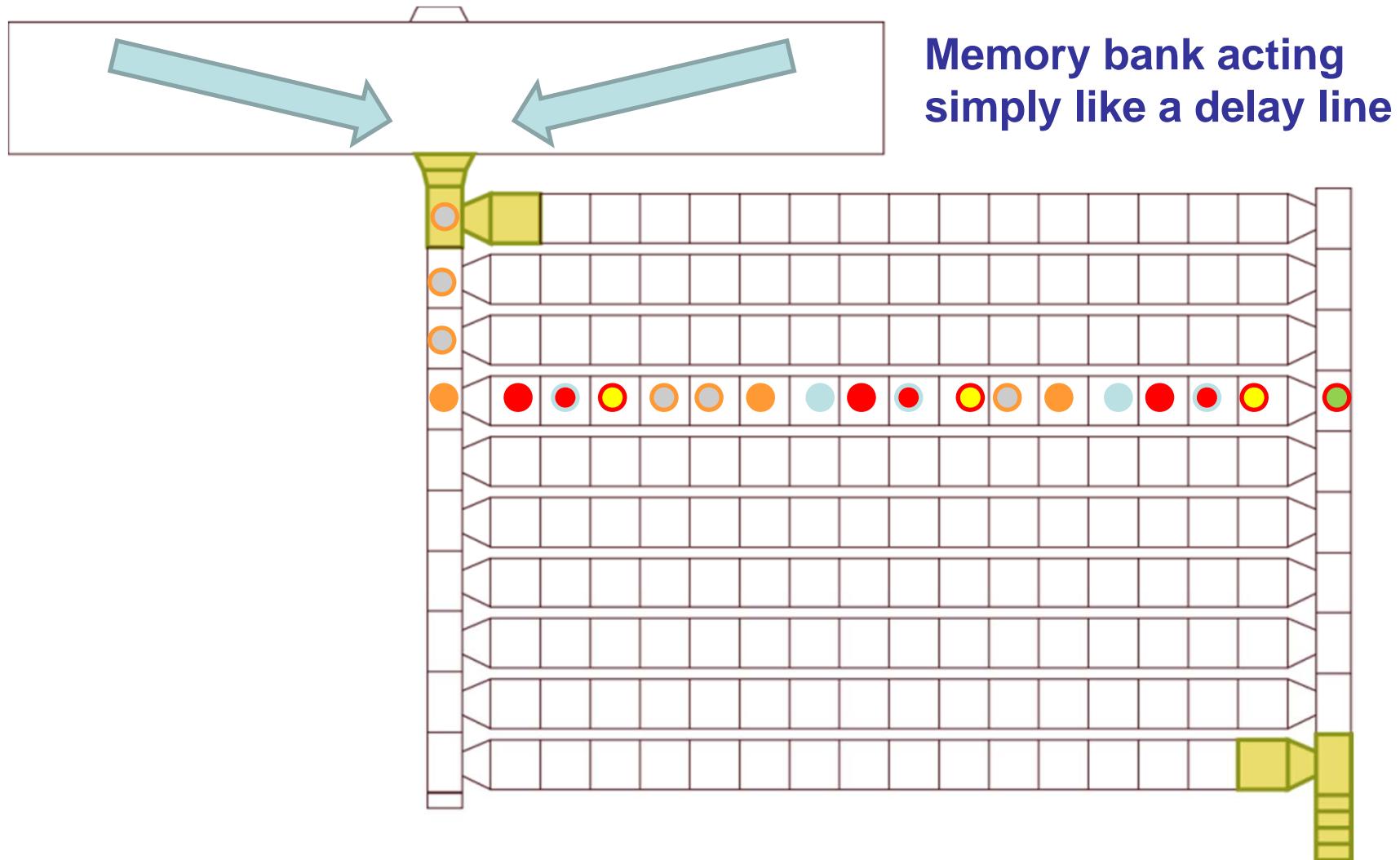


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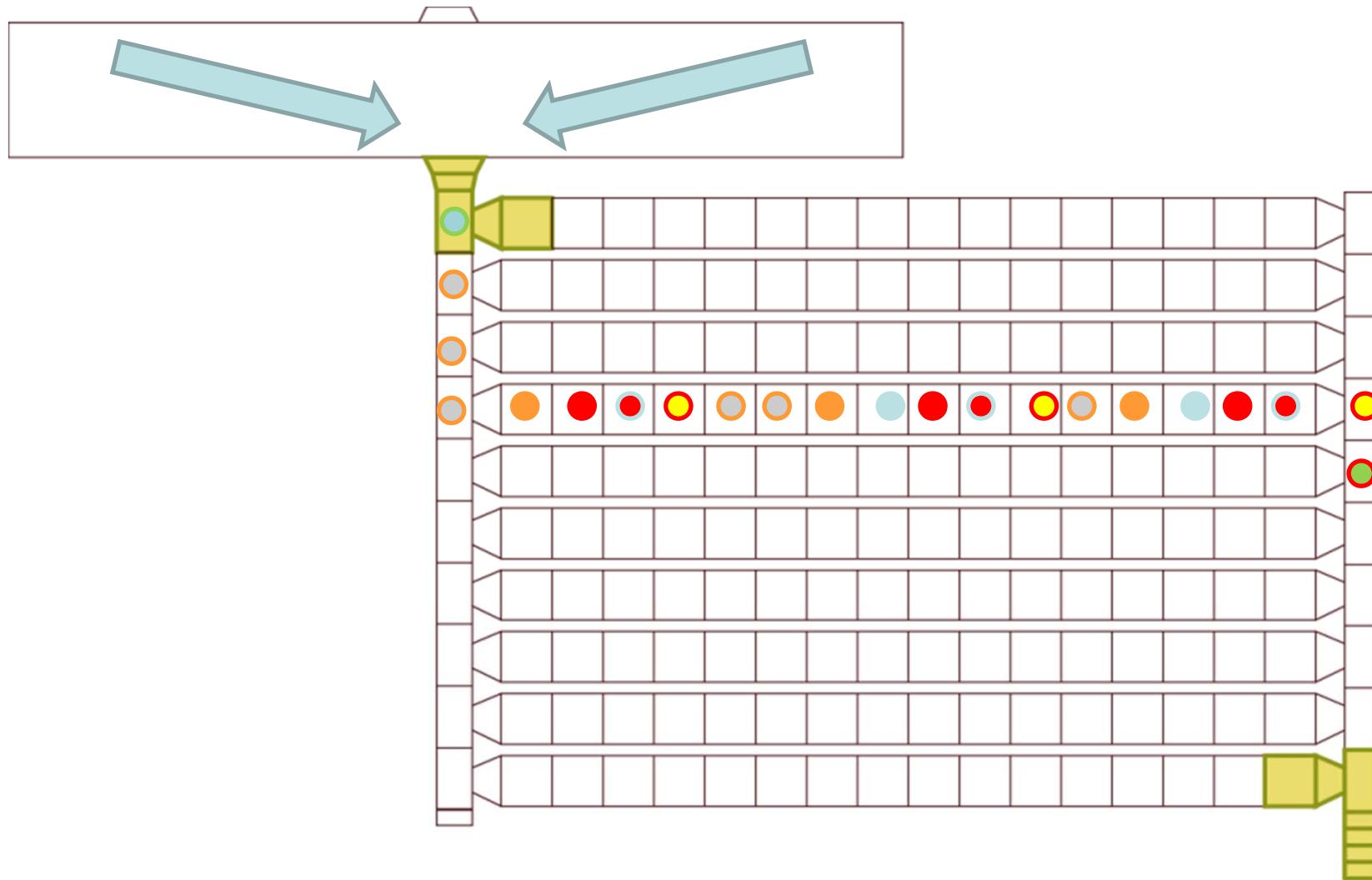


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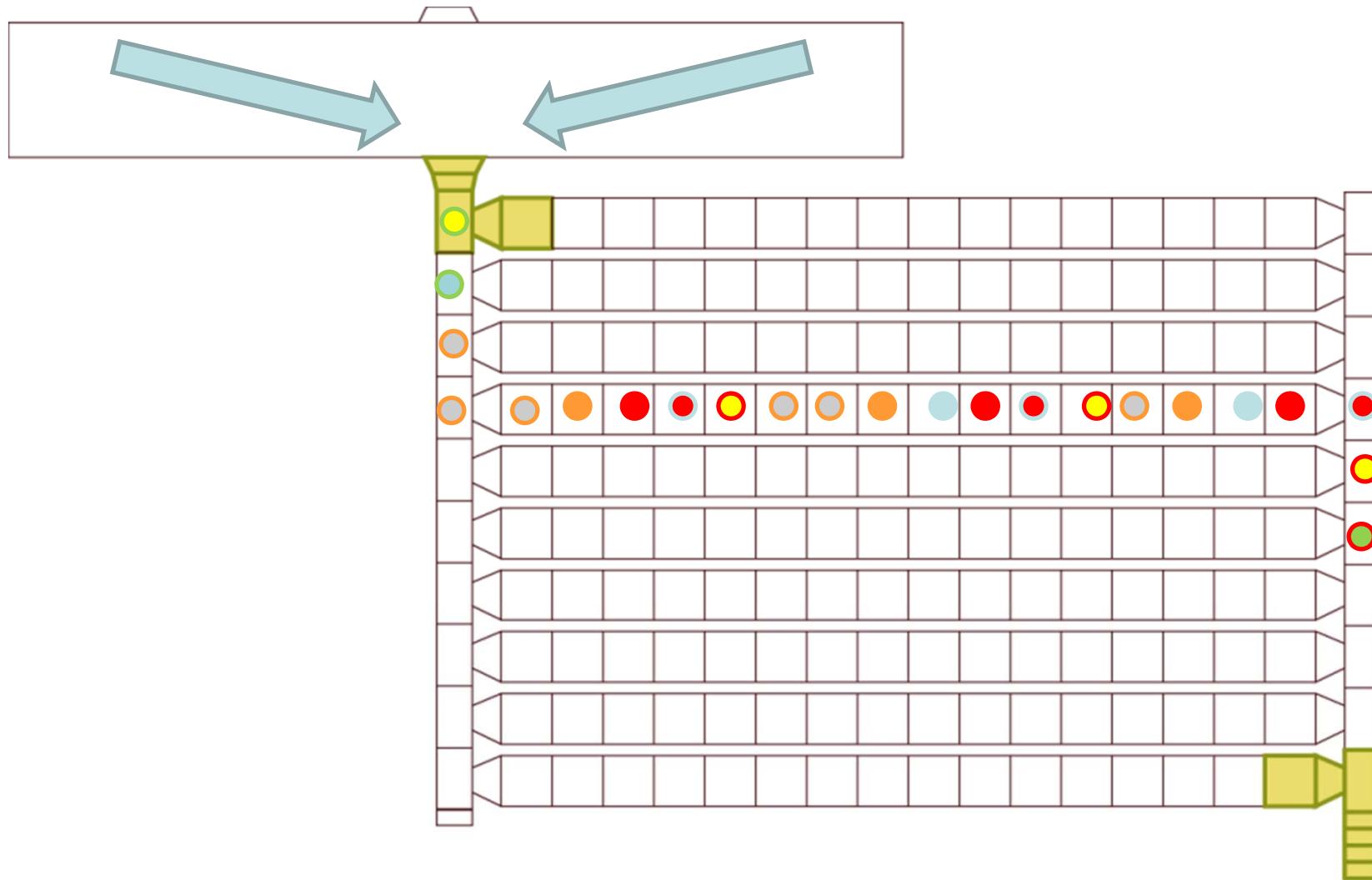


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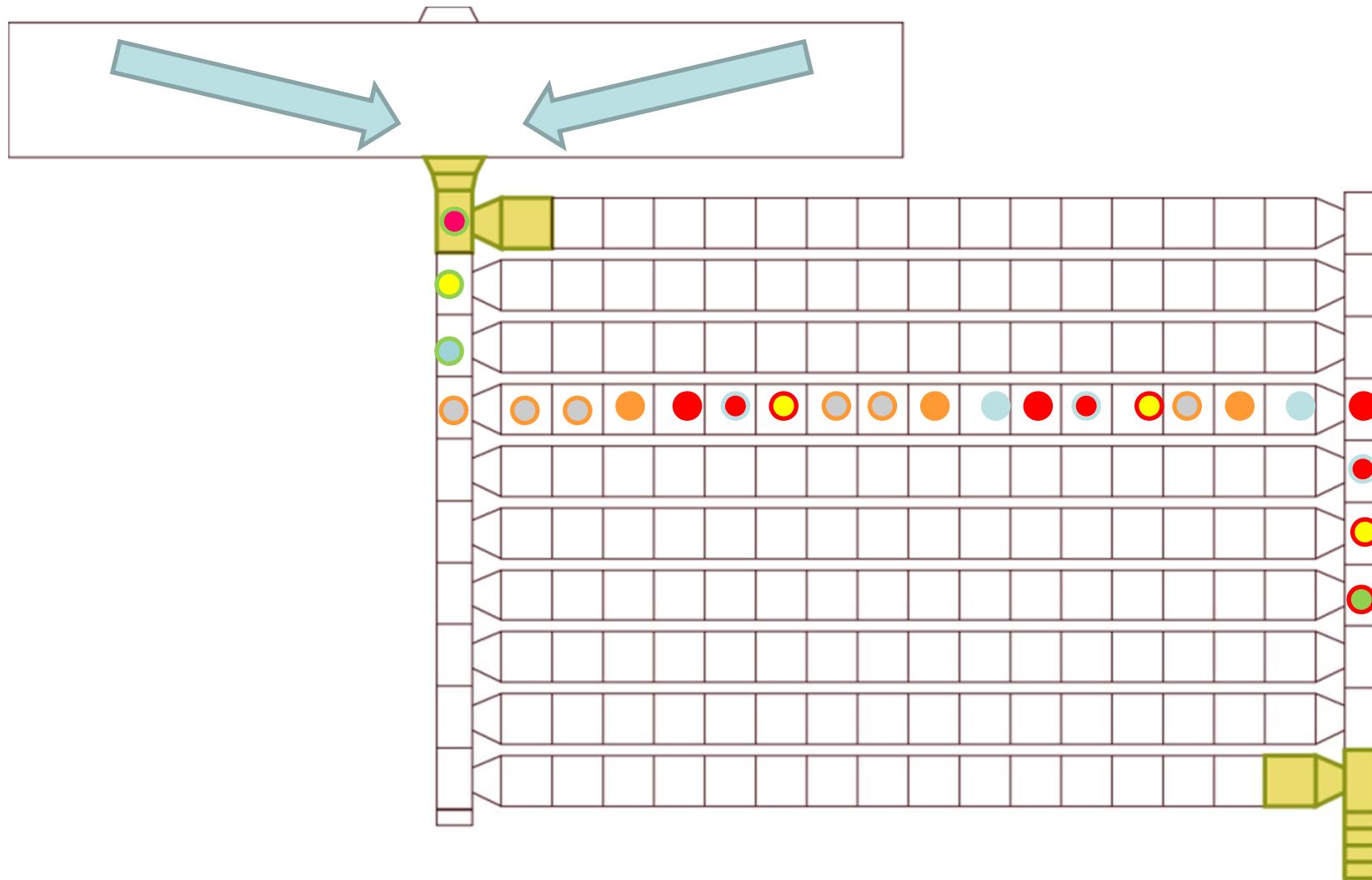


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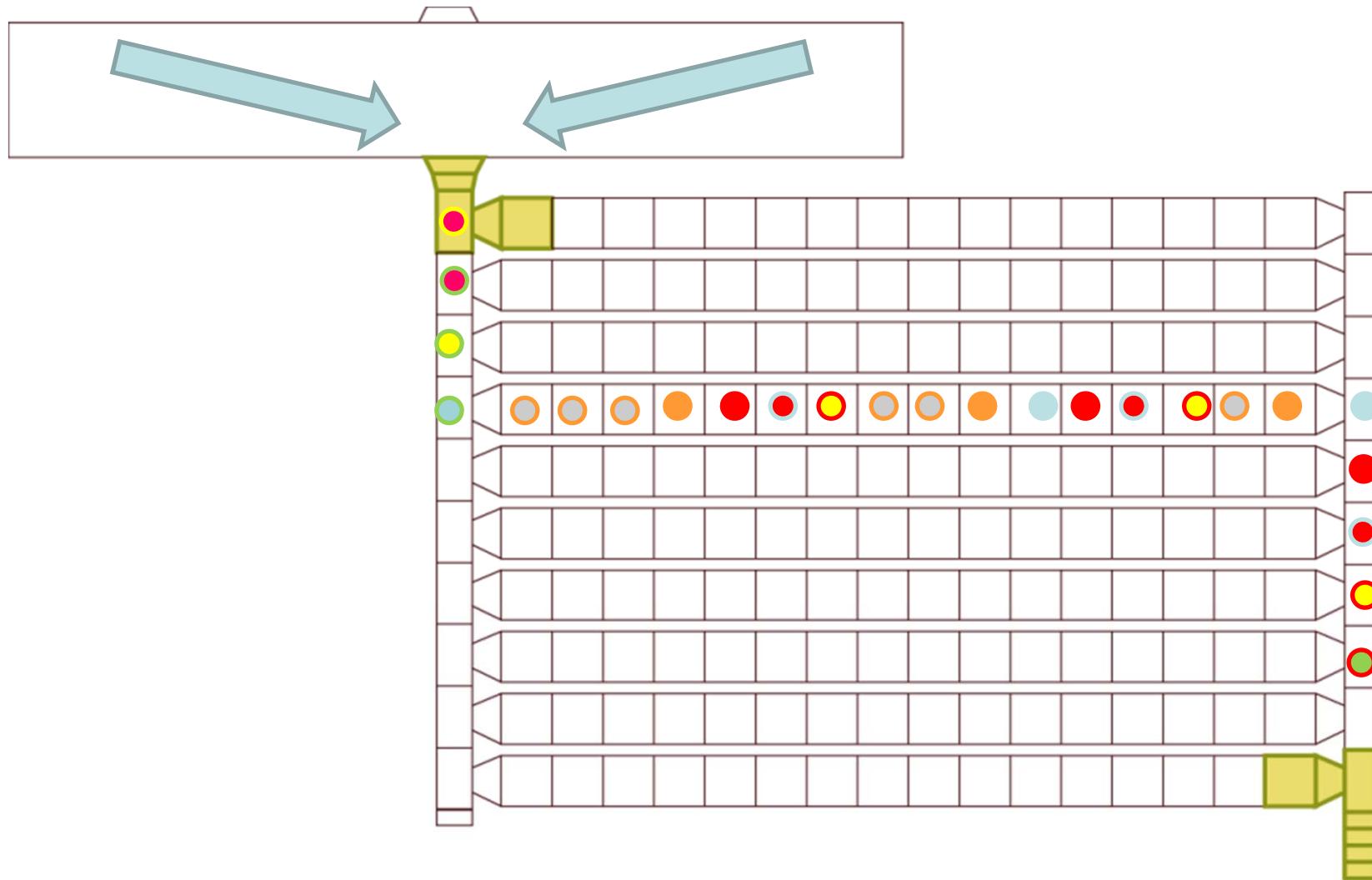


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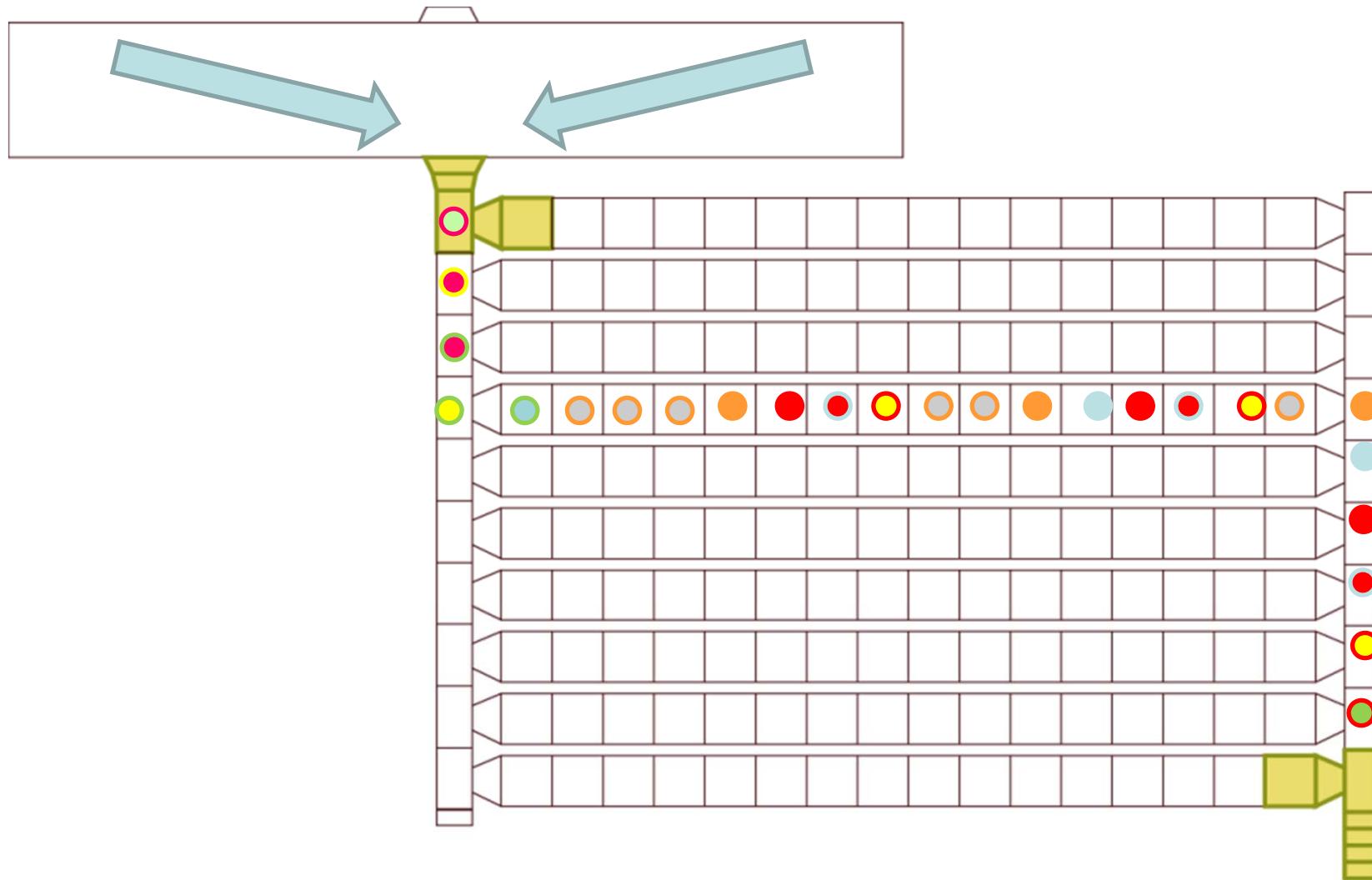


Continuous mode



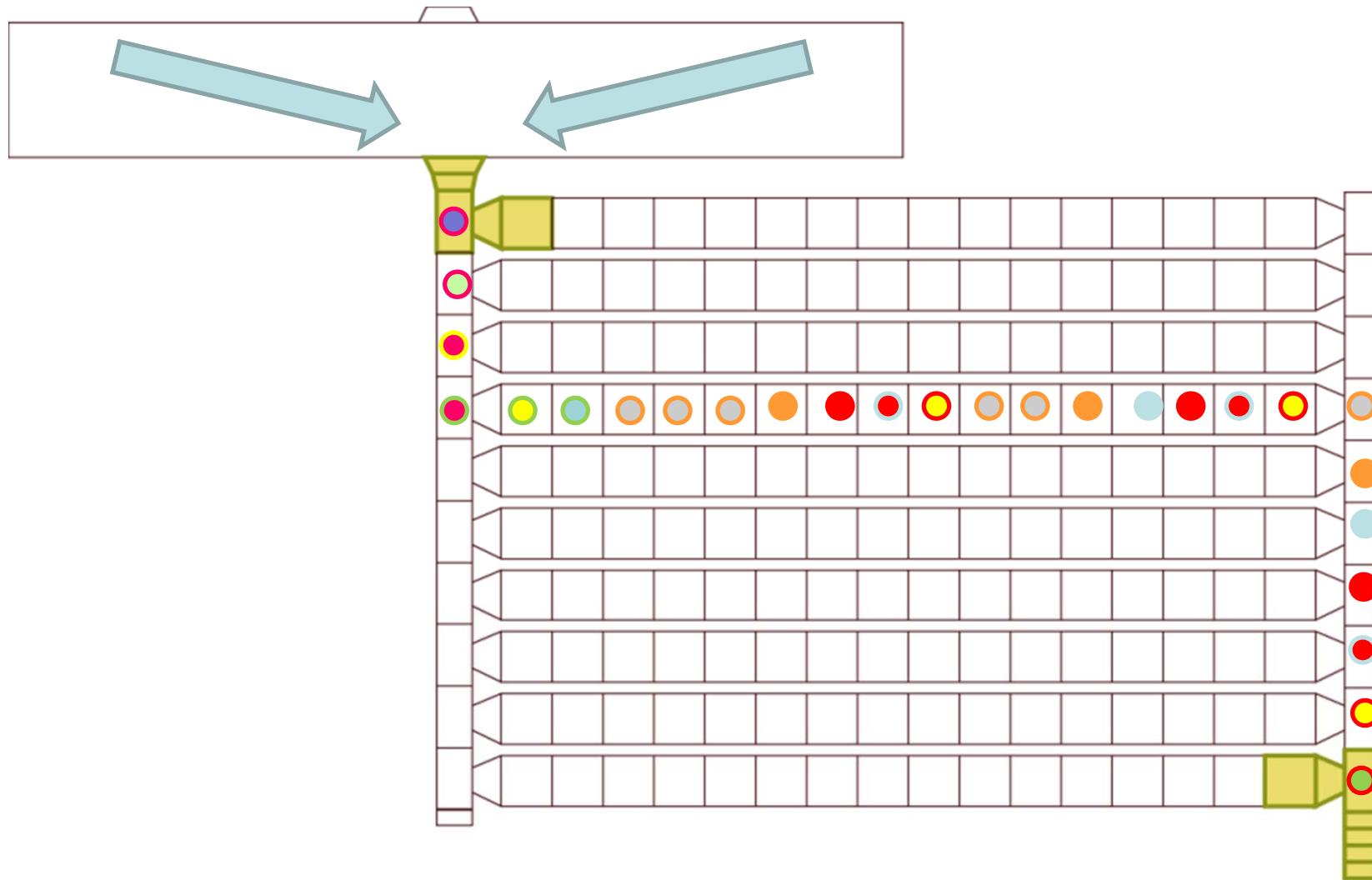


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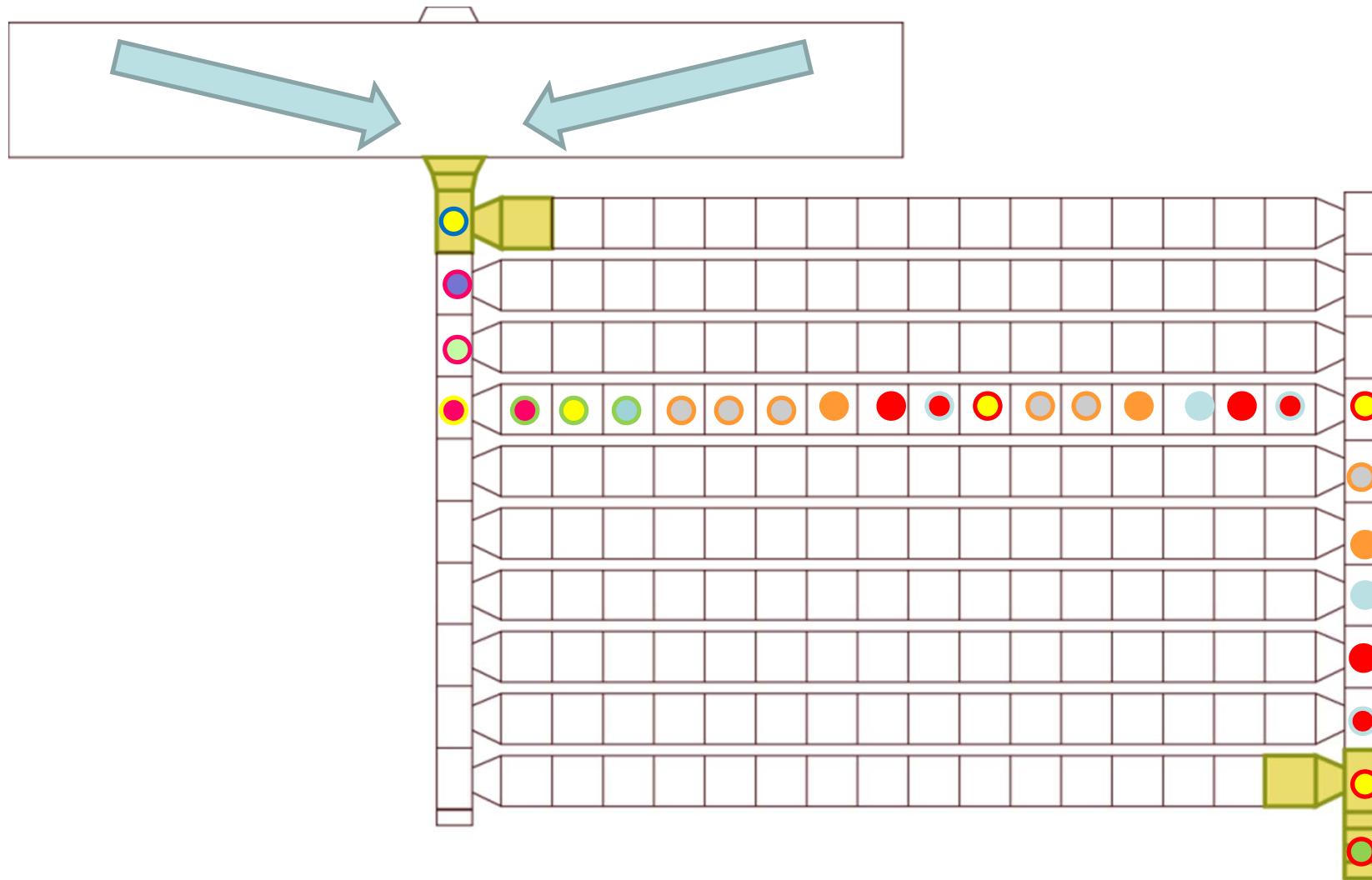


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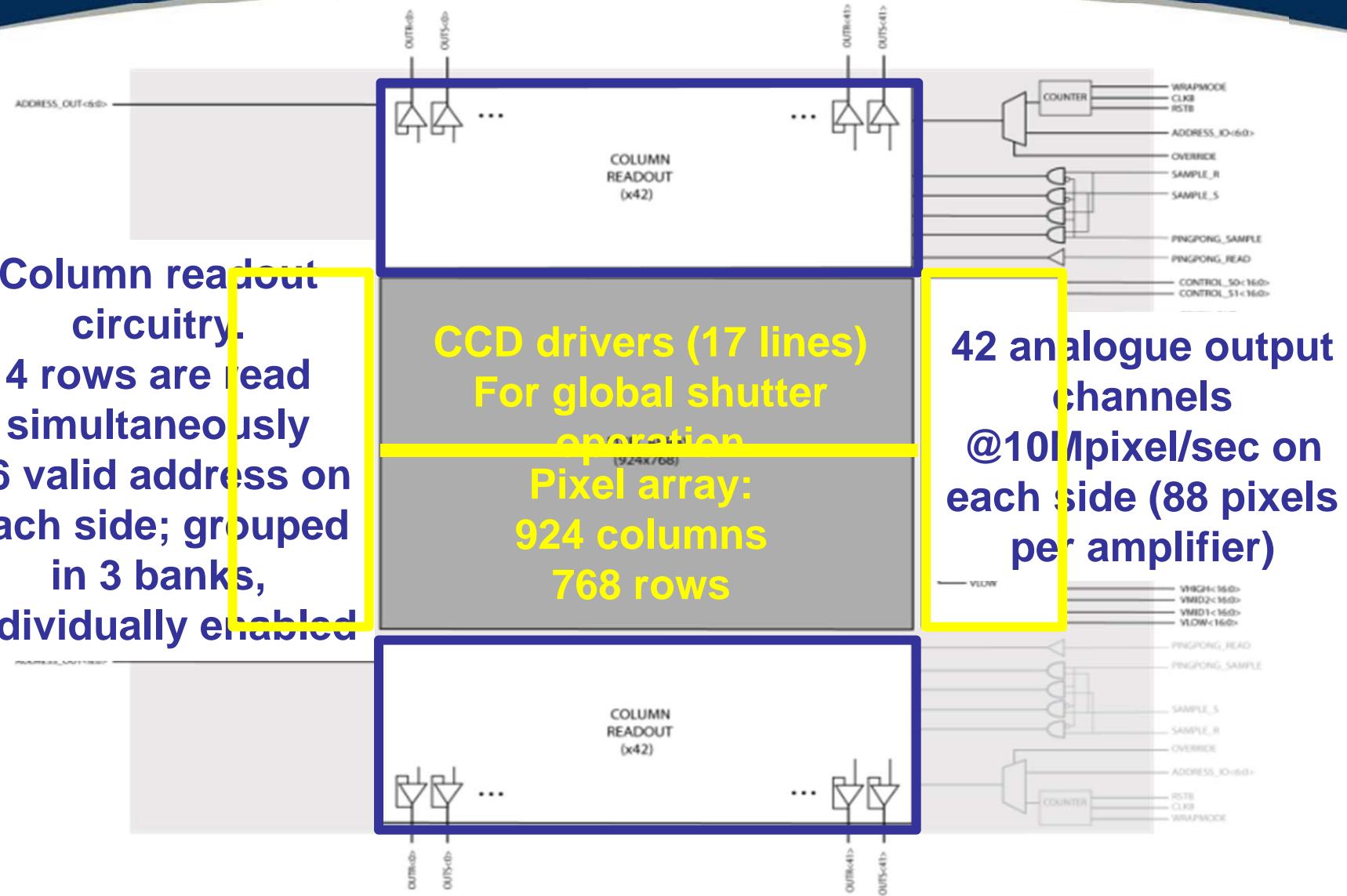


Continuous mode



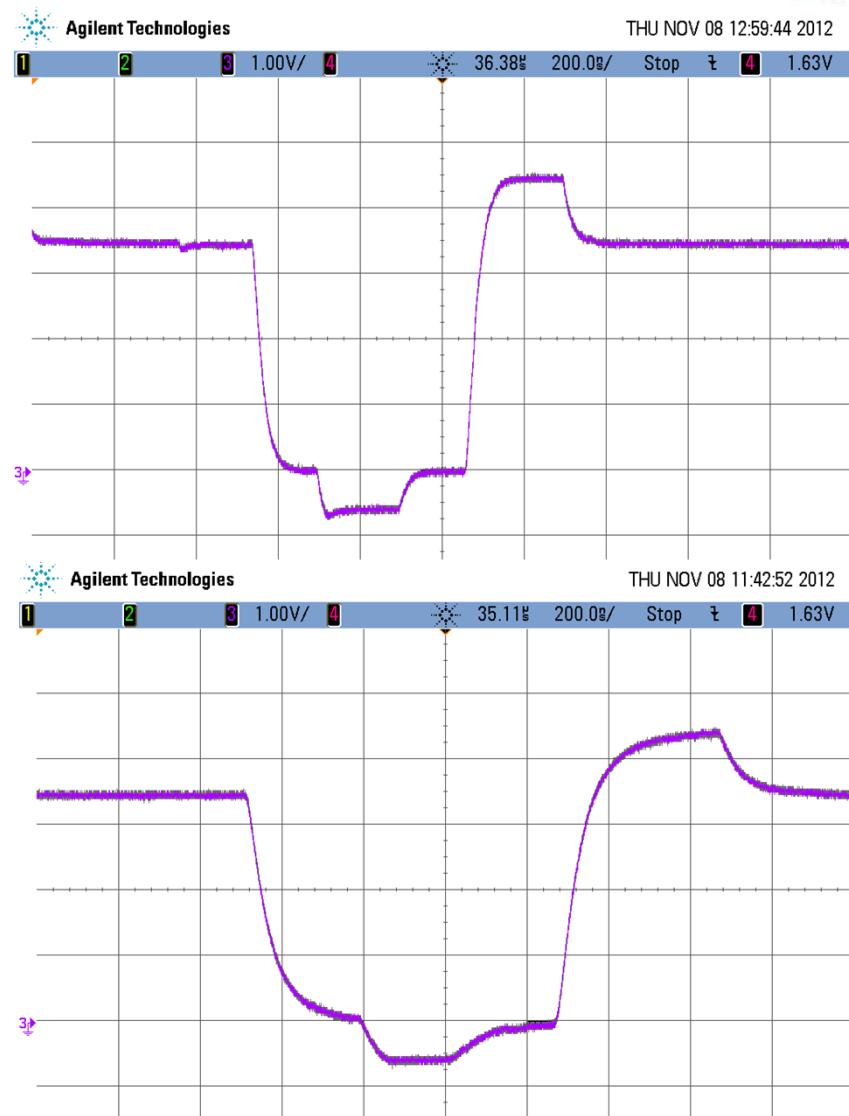
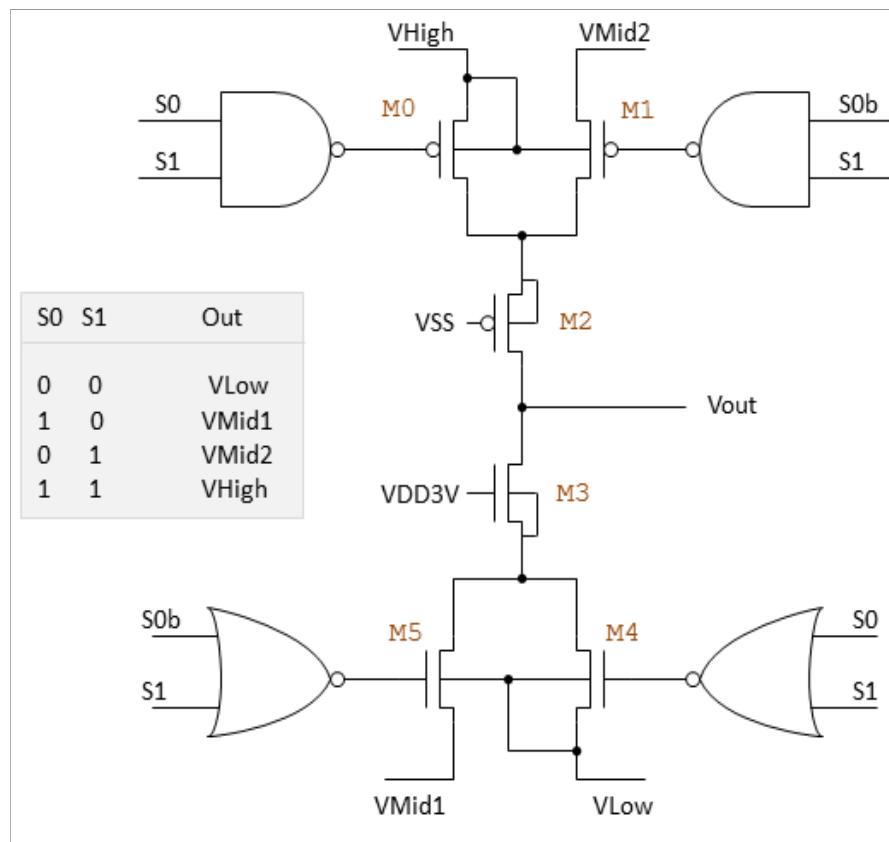


Sensor floorplan



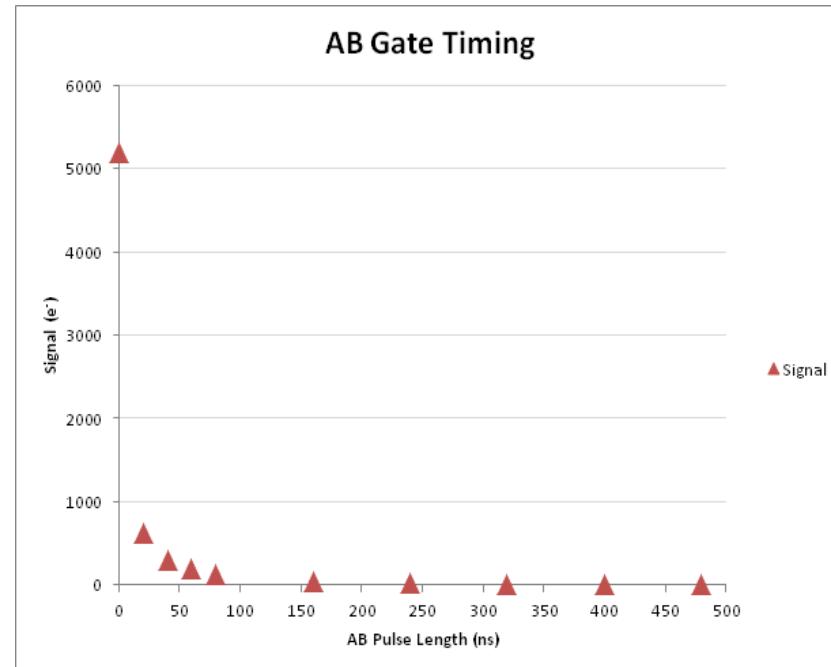
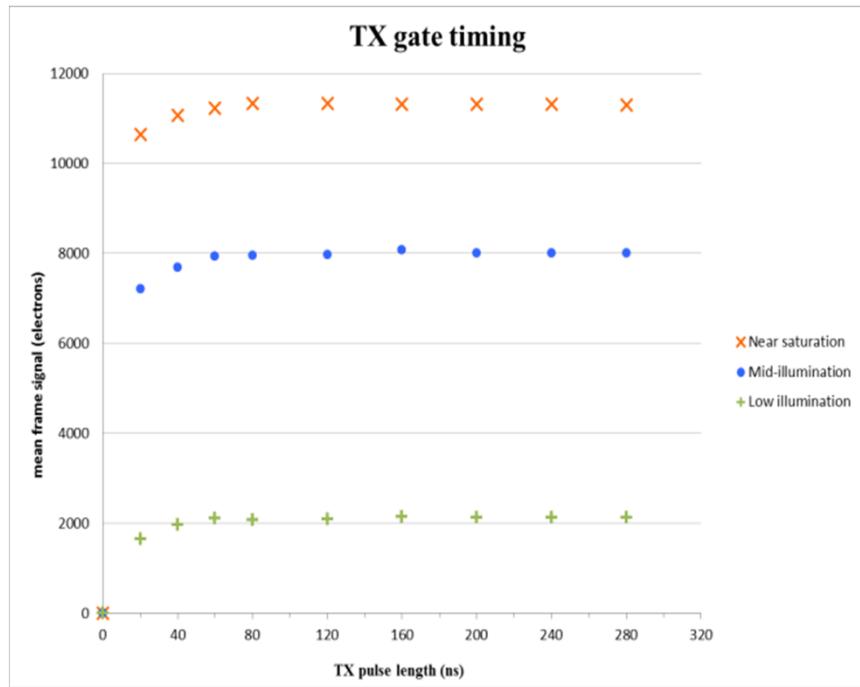


Allow multiple level drivers.
Signal range: -1V → 6V





Diode timing

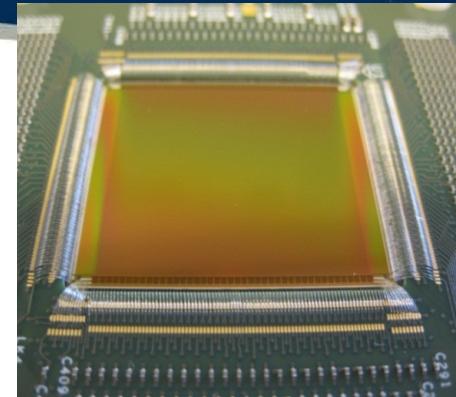


Shutter speed $<\sim 60$ ns



Performance summary

Parameter	Unit	Value
Pixel pitch (X)	um	30
Pixel pitch (Y)	um	30
Pixel format (X)		924
Pixel format (Y)		768
Number of pixels		709,632
Frame rate (burst mode)	fps	5,000,000
Frame rate (continuous mode)	fps	1,180
Pixel rate (burst mode)	Pixel/sec	3.5 T
Pixel rate (continuous mode)	Pixel/sec	0.84 G
Noise	e- rms	<10 e- rms
Full well capacity	e-	11,700
Camera gain	μ V/e-	80
Dynamic range		>1,170
	dB	61.4
	bit	10.2
Fill Factor		11%
Quantum efficiency	Without microlens	2.3% (red) 2.2% (blue)

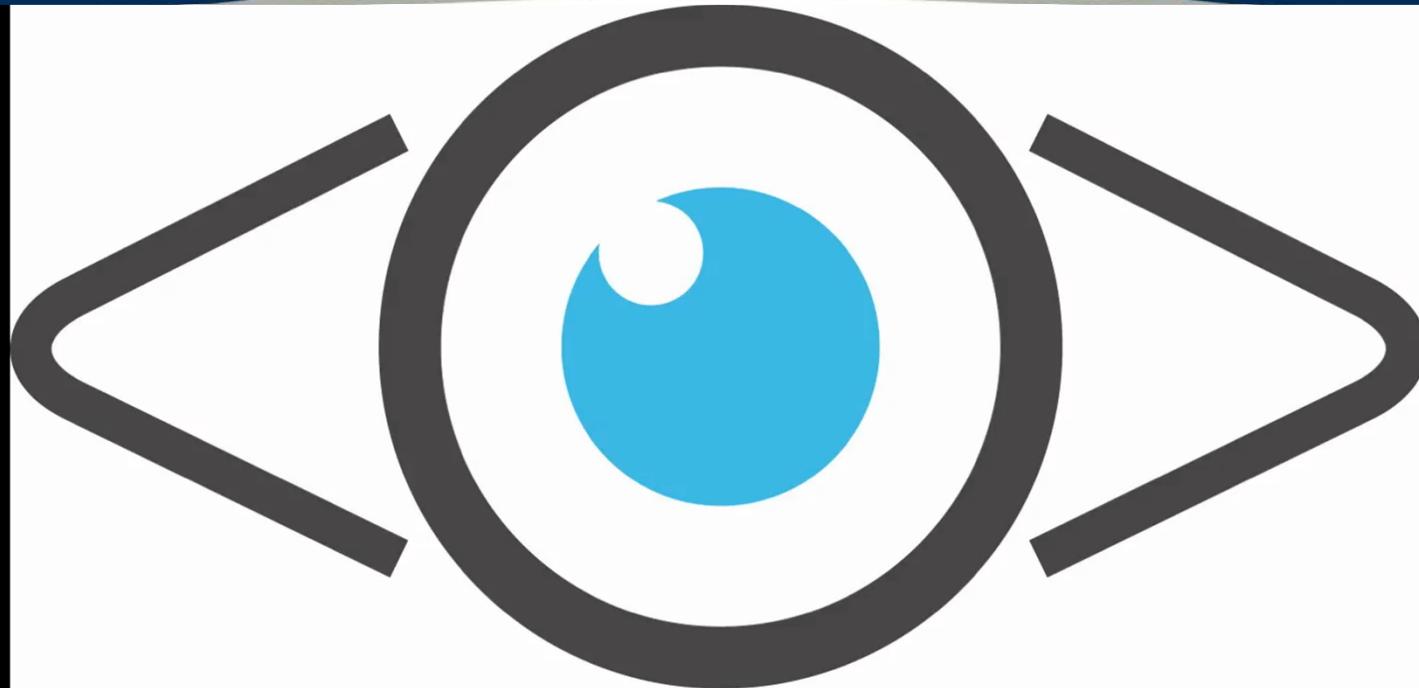


First manufactured on standard epi: 5.5 μ m thickness, low resistivity.

New, improved version made on high-res epi and microlenses just received from manufacturing



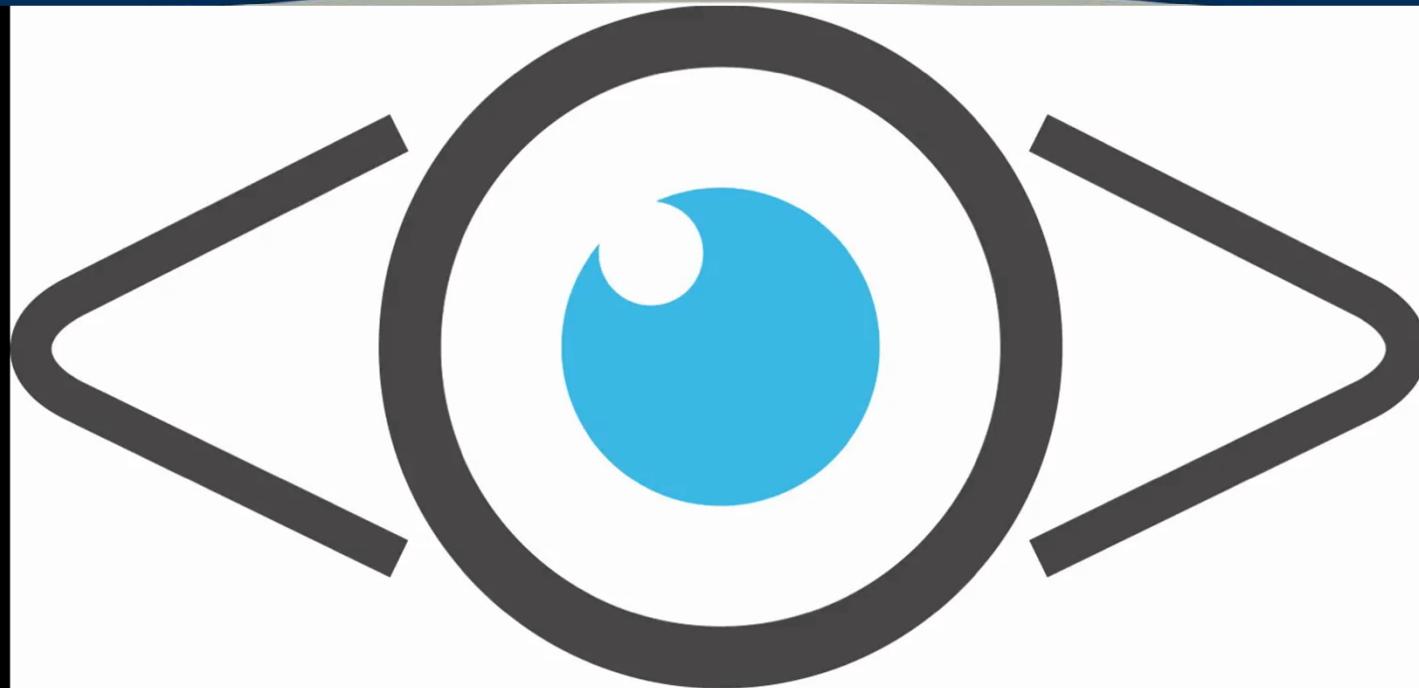
Imaging examples



**specialised
imaging**



Imaging examples



**specialised
imaging**



... and also

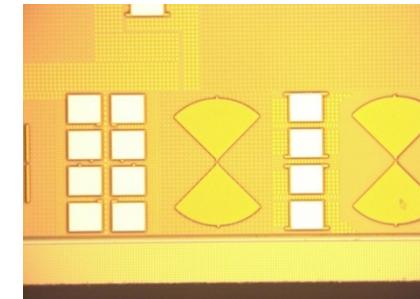
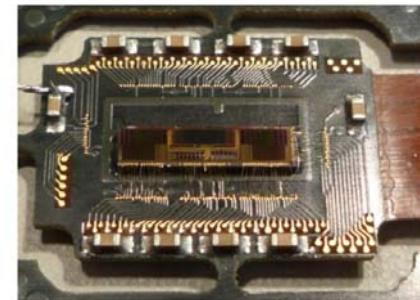
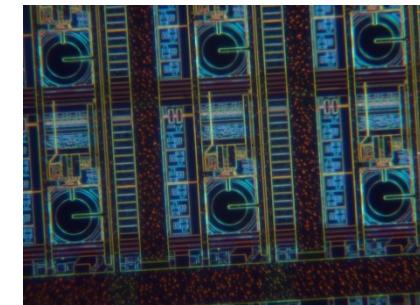
More CMOS image sensors
developed
(www.dsc.stfc.ac.uk/cmossensors)

Sensors for Alice at CERN-LHC

Single Photon Avalanche Detector
(SPAD) array

Highly Miniaturised Radiation
Monitor (HMRM) for ESA

Terahertz detectors





Broad span of technologies developed at STFC-RAL:
detectors, ASIC, DAQ, software, mechanics, cooling, ...

Hybrid detectors: Hexitec, LPD, ...

CMOS image sensors: focus on science applications,
with efficient transfer to industry

Large area sensors up to wafer-scale: Achilles for TEM
in production, Lassena for medical imaging, Percival
for low-energy X-ray detectors.

Ultra-high speed sensors: PIMMS for mass spec, Kirana
for imaging
and more!



Acknowledgements

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Cambridge)

G. van Hoften (FEI)

M. Brouard, C. Vaillance, R. Nickerson et al. (Oxford University)

W. Chan, K. Taylor (Specialised Imaging)

A. Fenigstein, A. Lahav (TowerJazz Semiconductor)

...

See also

www.dsc.stfc.ac.uk/cmossensors



The last slide

Questions?

www.dsc.stfc.ac.uk/cmossensors